

ESR Experiments on a Single Donor in Silicon

L. A. Tracy, D. R. Luhman, S.M. Carr, J. Borchardt,
N.C. Bishop, G.A. Ten Eyck, T. Pluym, J. Wendt, W. Witzel,
R. Blume-Kohout, E. Nielsen, M.P. Lilly, M.S. Carroll

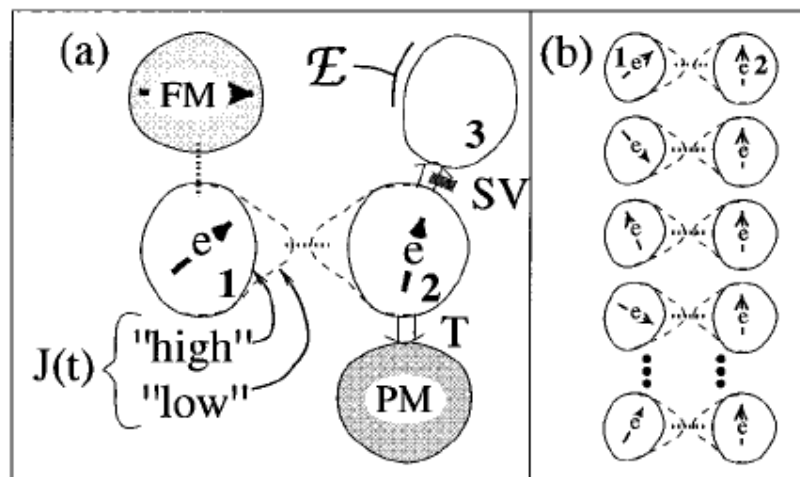
Sandia National Laboratories



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Semiconductor spin qubits

coupled quantum dots

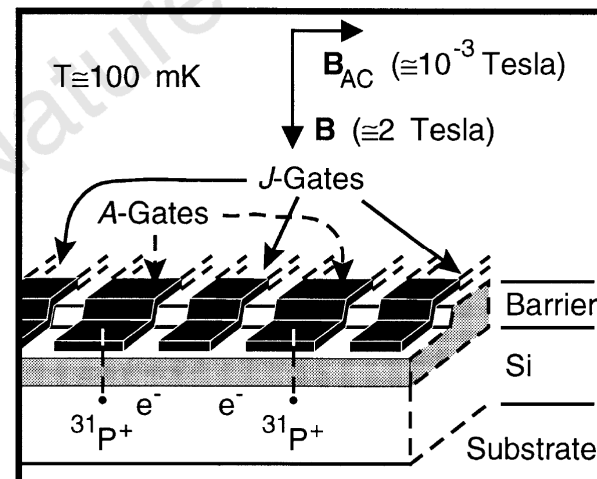


D. Loss and D. P. DiVincenzo,
Phys. Rev. A **57**, 120 (1998)

DiVincenzo criteria:

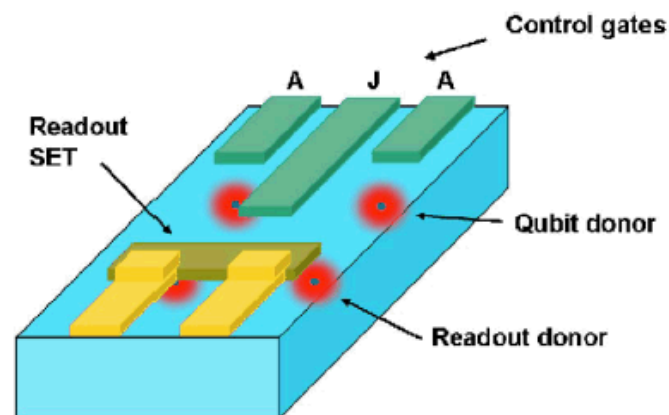
- identification of well-defined qubits
- reliable state preparation
- low decoherence
- accurate quantum gate operations
- strong quantum measurements

donor nuclear spin qubits



B. E. Kane, Nature **393**, 133 (1998)

donor electron spin qubits

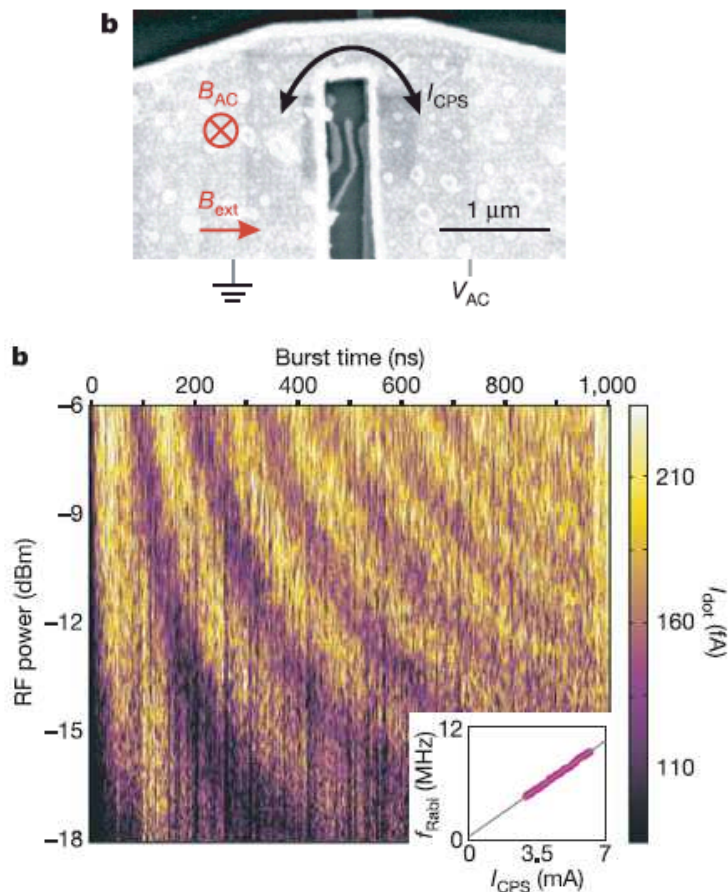


C. D. Hill *et al.*, Phys. Rev. B **72**, 045350 (2005)

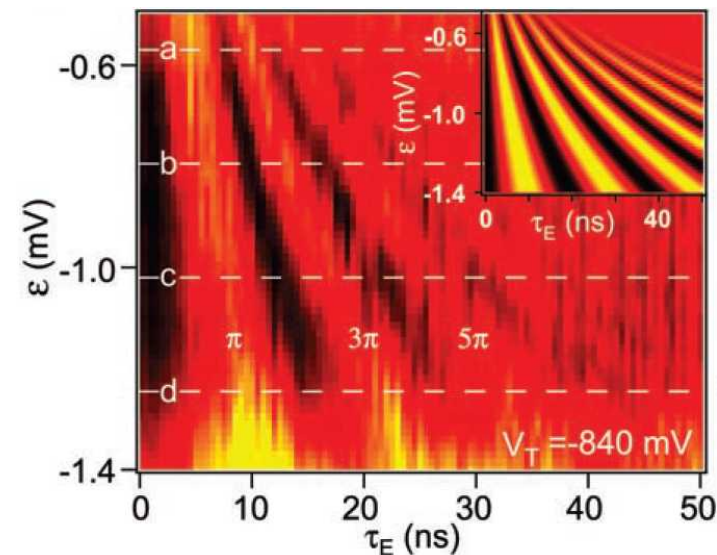
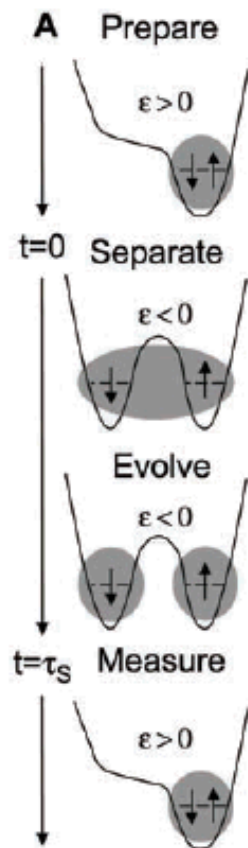
GaAs quantum dot spin qubits

coherent single spin oscillations

singlet-triplet qubit



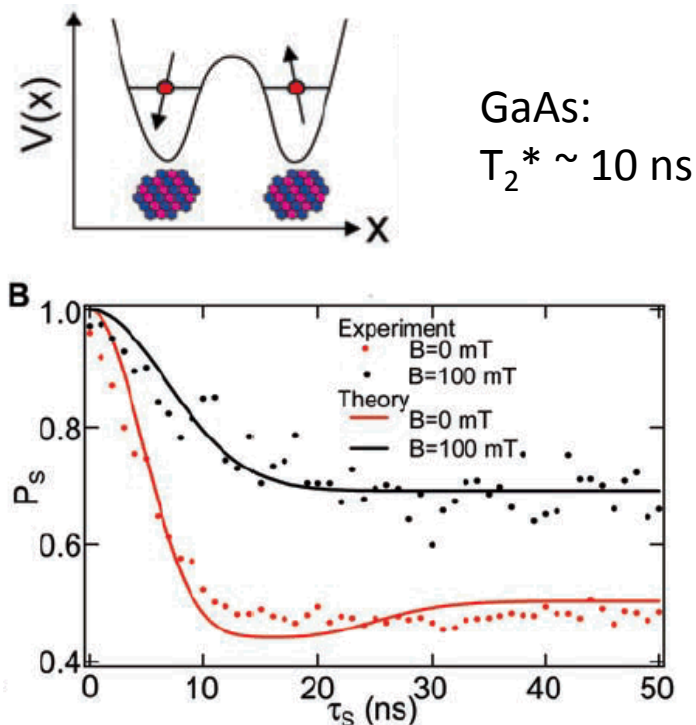
F. H. L. Koppens *et al.*, Nature **442**, 766 (2006)



J. R. Petta *et al.*, Science **442**, 766 (2005)

Nuclear spins

Nuclear spins in GaAs

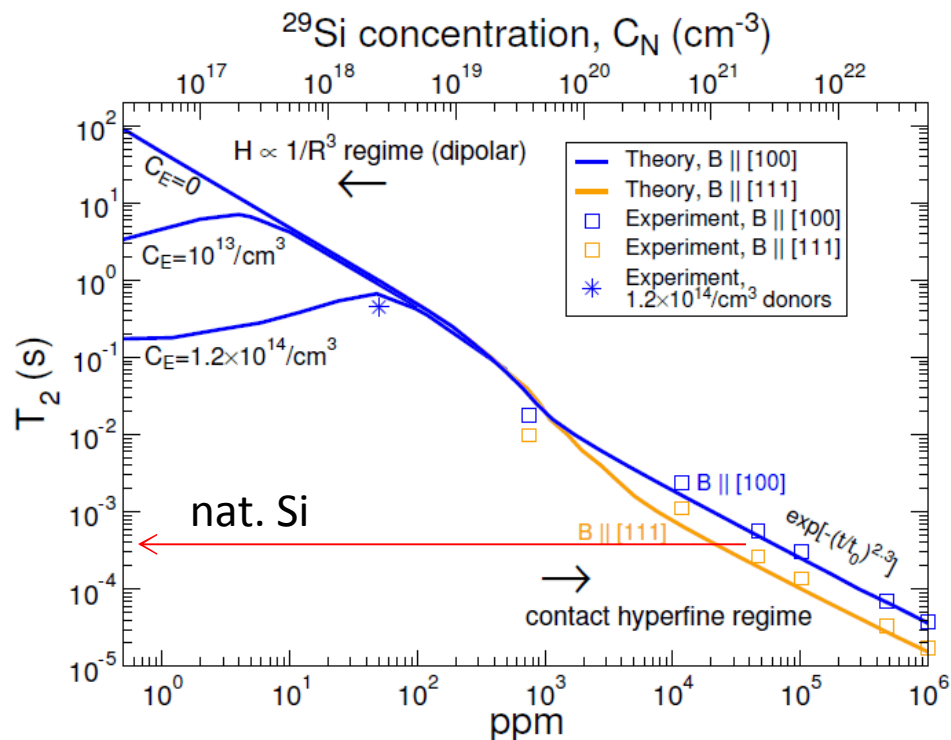


J. R. Petta *et al.*, Science **442**, 766 (2005)

$$T_2^{\text{GPMG}} \sim 200 \mu\text{s}$$

H. Bluhm *et al.*, Nature **7**, 109 (2011)

T_2 in bulk P doped ^{28}Si



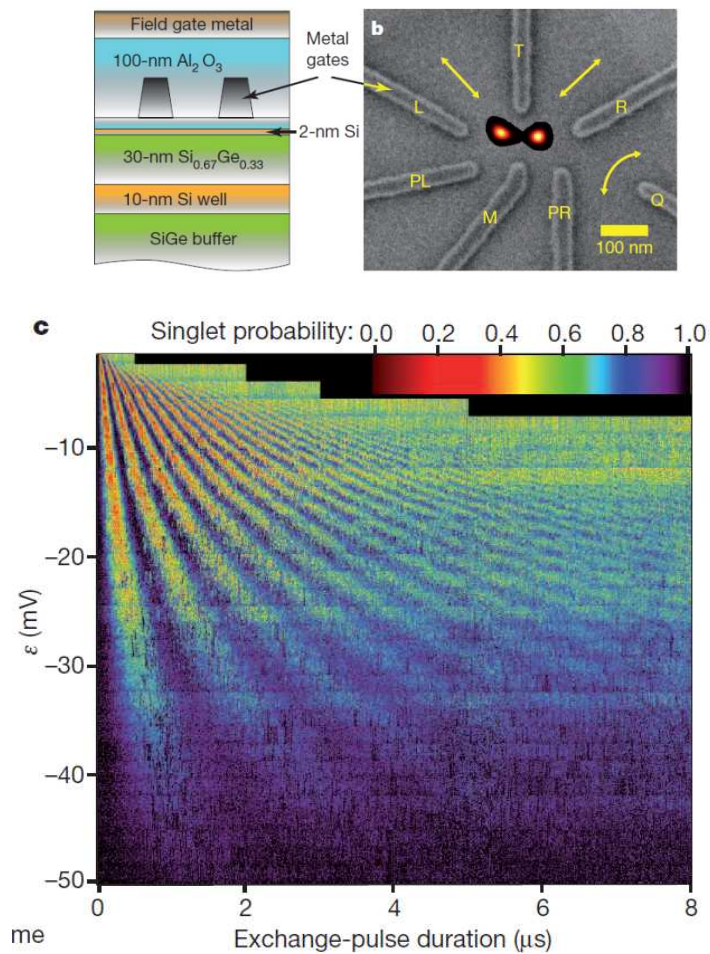
W. Witzel *et al.*, Phys. Rev. Lett. **105**, 187602 (2010)

E. Abe *et al.*, Phys. Rev. B **82**, 121201R (2010)

A. M. Tyryshkin *et al.*, Nat. Mat. **11**, 143 (2012)

Silicon spin qubits

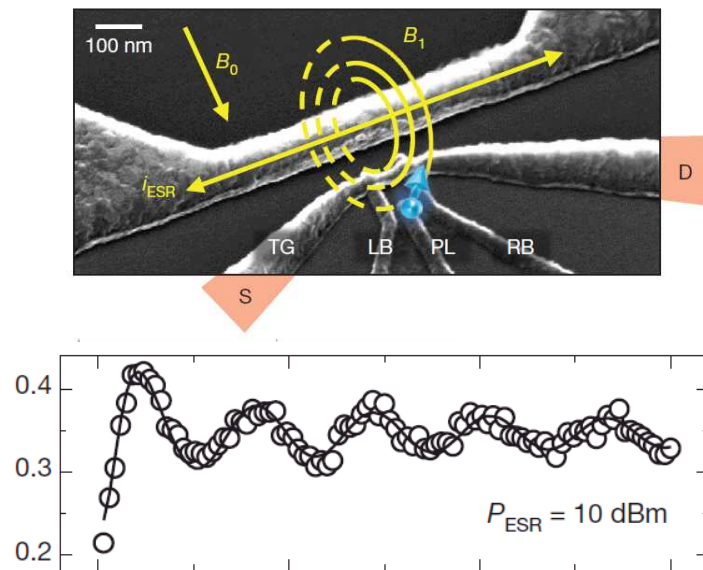
SiGe quantum dot



$$T_2^* = 360 \text{ ns}$$

B. M. Maune *et al.*, Nature **481**, 344 (2012)

Donor qubit



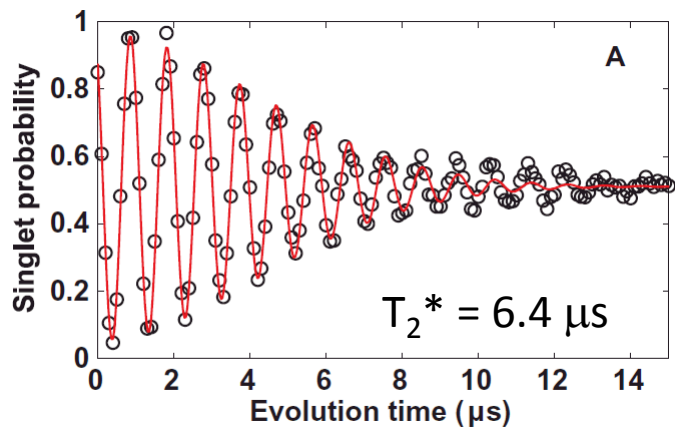
$$T_2^* = 55 \text{ ns}$$

$$T_2^{\text{echo}} = 200 \text{ } \mu\text{s}$$

J. Pla *et al.*, Nature **489**, 541 (2012)

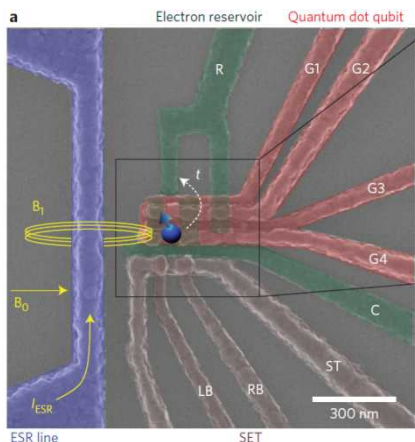
Enriched ^{28}Si devices

SiGe triple dot



K. Eng *et al.*, Sci. Adv. (2015)

Si MOS quantum dot

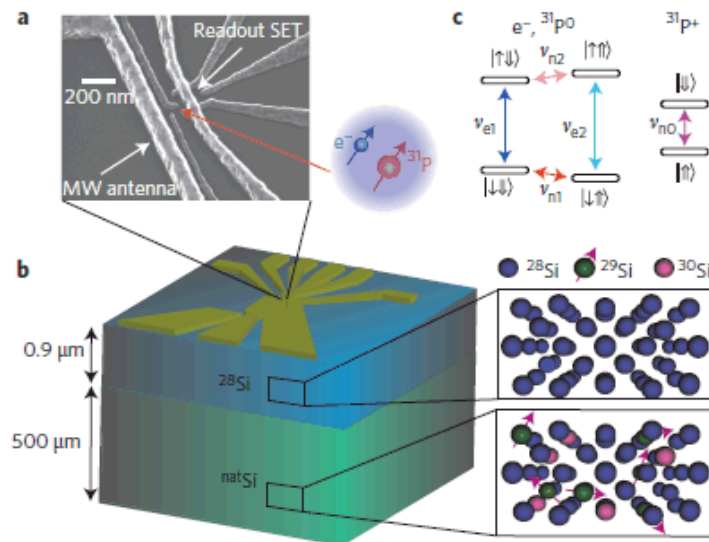


$$T_2^* = 120 \mu\text{s}$$

$$T_2^H = 1.2 \text{ ms}$$

M. Veldhorst *et al.*, Nature Nanotech. **9**, 981 (2014)

Single donor qubit



$$T_2^* = 270 \mu\text{s}$$

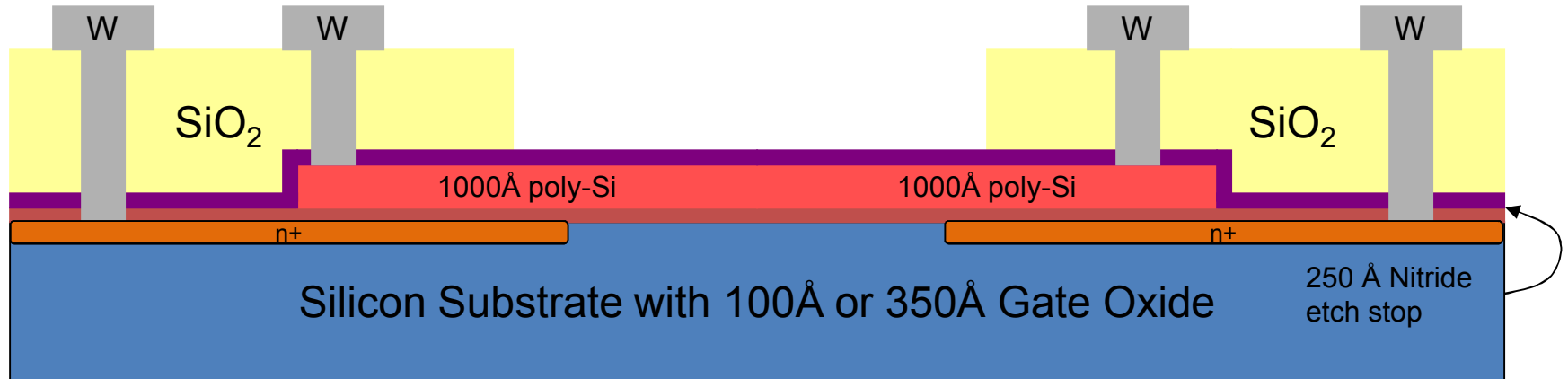
$$T_2^H = 0.95 \text{ ms}$$

J. T. Muhonen *et al.*, Nat. Nanotech. **9**, 986 (2014)

Outline

- Device fabrication
- Single spin readout and initialization
- Natural silicon qubit
- Enriched silicon 28 qubit

Si donor qubit fabrication – SNL Si foundry



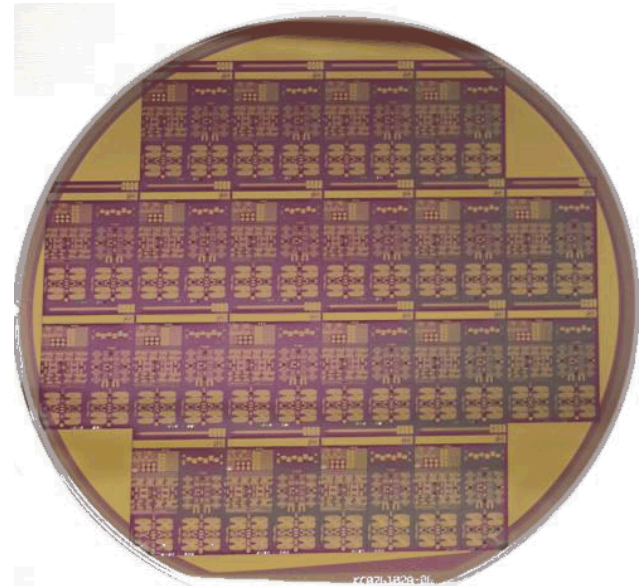
MOS Stack from Si fab

Many electron QDs possible with 0.18 μm litho

Structures fabricated for external community

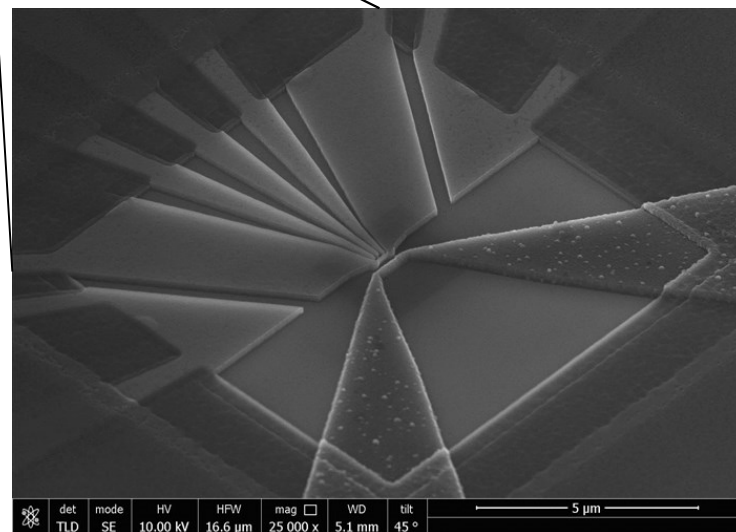
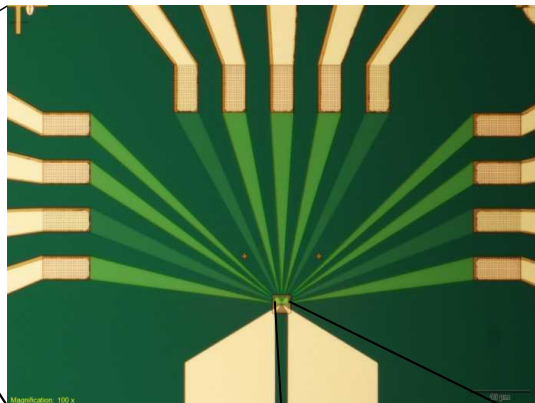
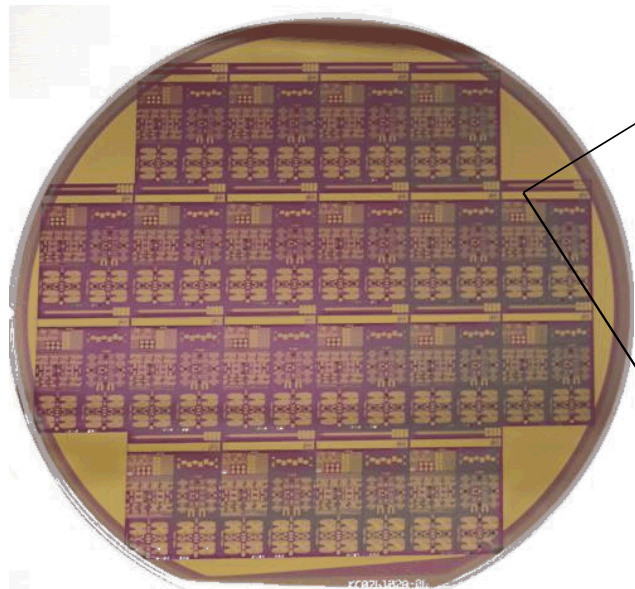
(NIST, LBNL, CQC2T, U. Princeton)

7,500 – 15,000 4K mobility

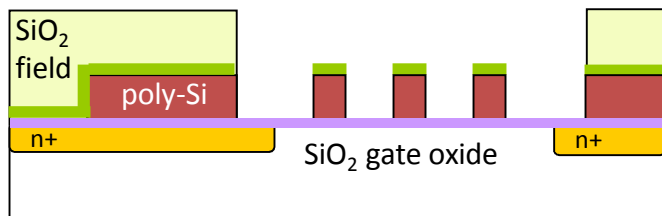


T. Pluym, G. A. Ten Eyck, N. Bishop,

Nanostructure fabrication

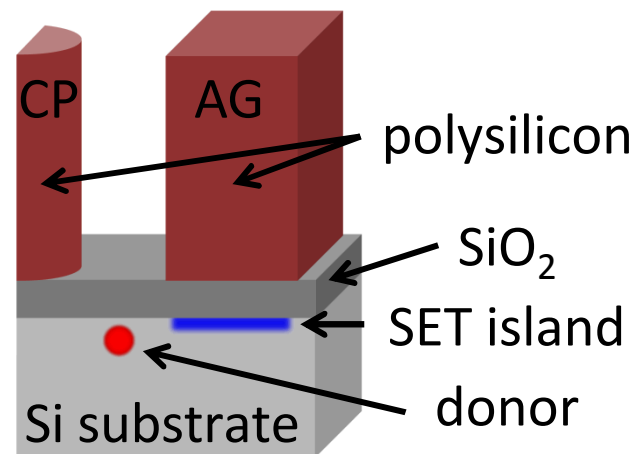
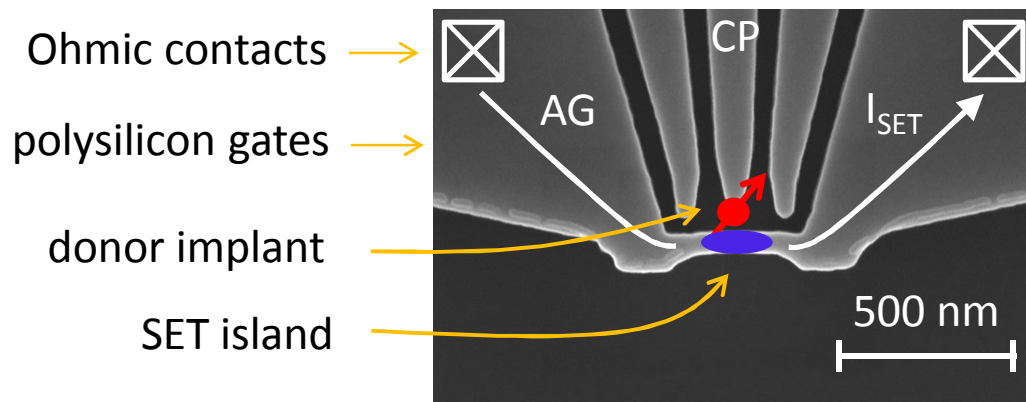


EBL and poly etch to define nanostructure gates

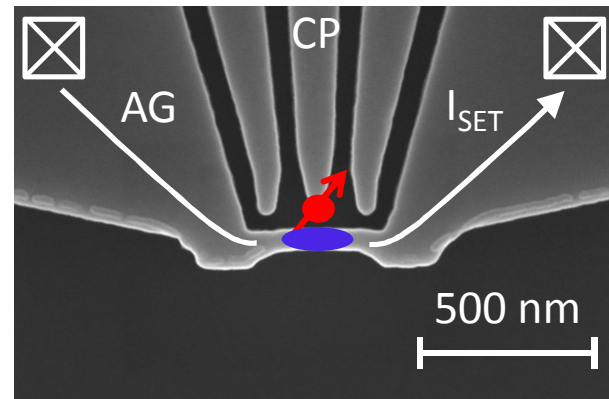
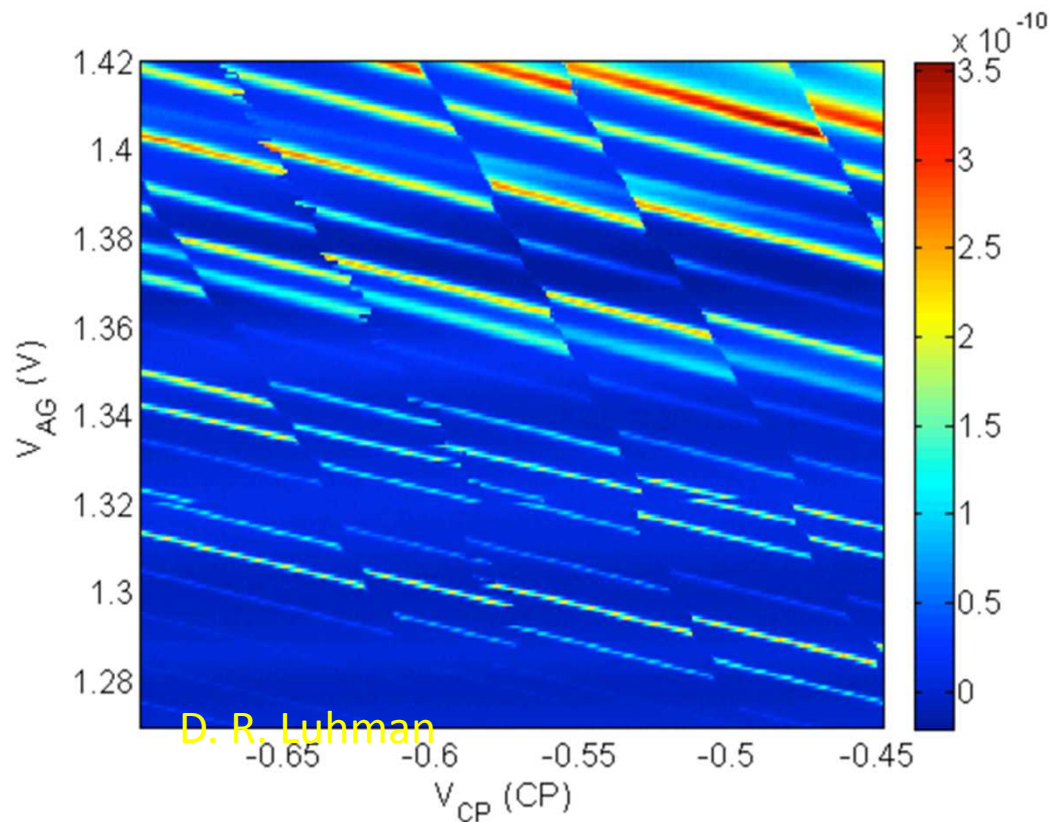


Donor electron spin readout device

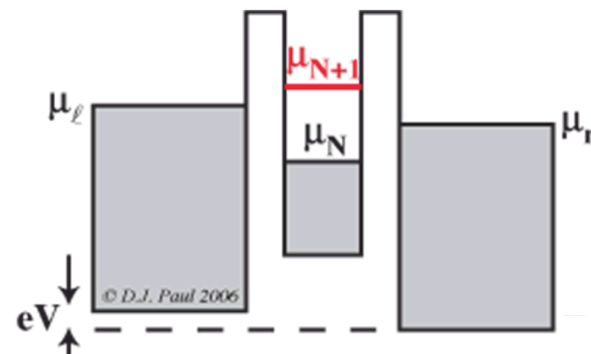
- Polysilicon gates used to form single electron transistor (SET) at Si/SiO₂ interface
- Timed implant with PMMA window, self-aligned with polysilicon gates
- Implant range ~28 - 15 nm below SiO₂/Si interface, ~18 - 44 nm straggle (Sb@120 keV vs. P@45 keV)
- $4 \times 10^{11}/\text{cm}^2$ dose $\rightarrow$ ~15 donors in $60 \times 60 \text{ nm}^2$ window



Transport through SET

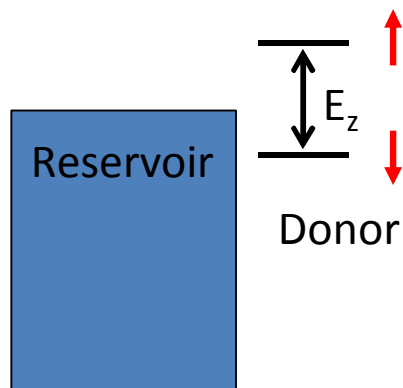


Coulomb blockade in quantum dot



Coulomb blockade in SET has discontinuities due to donor charge transitions (donor electron tunneling to SET island)

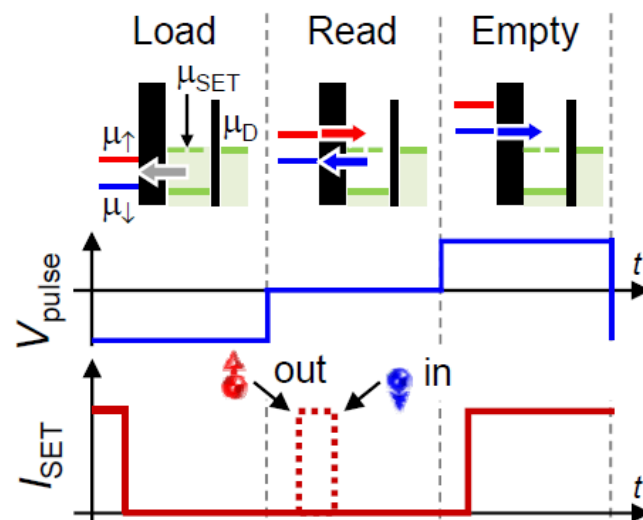
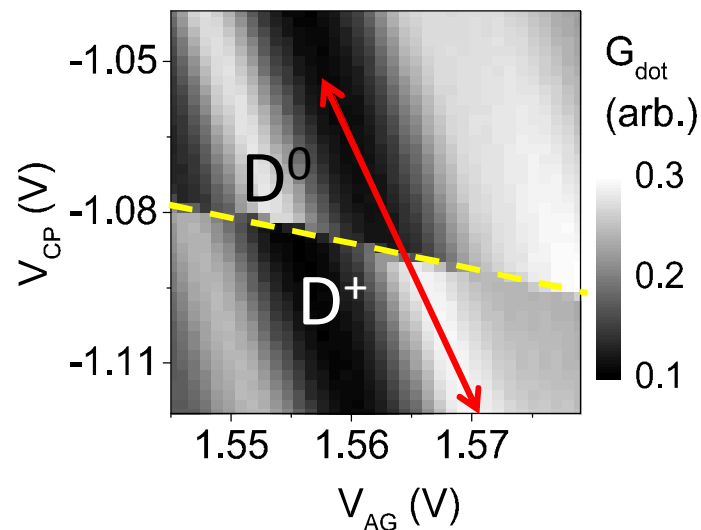
Single spin readout



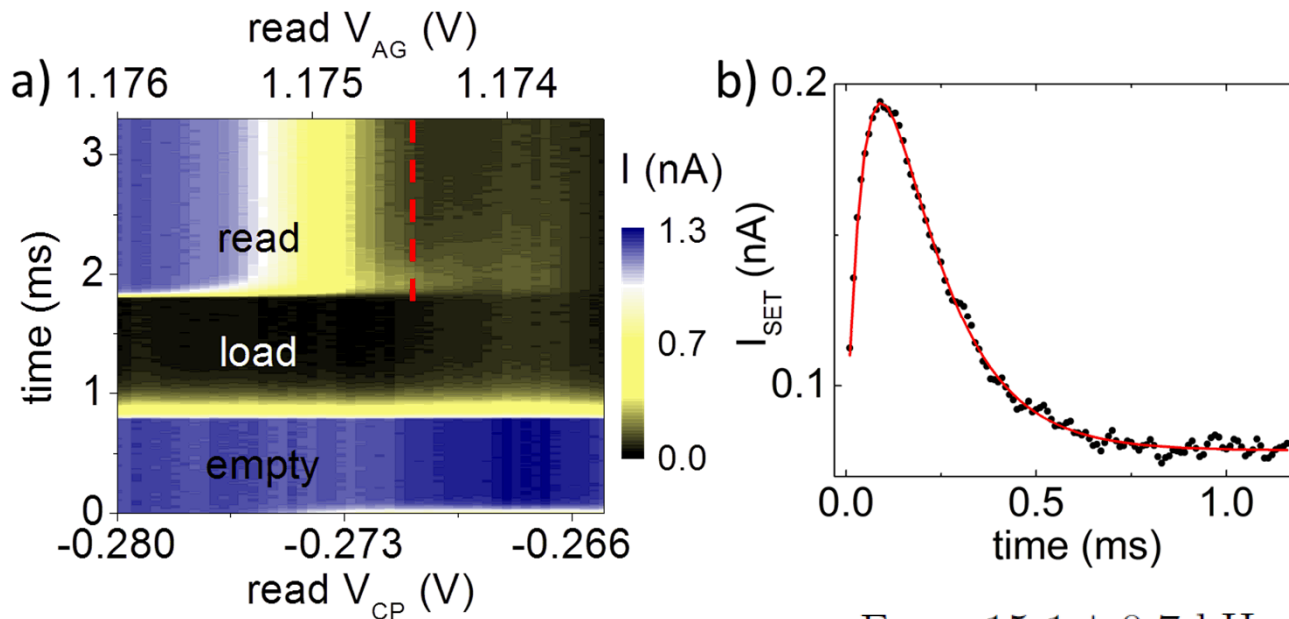
- Spin selective tunneling from donor to reservoir in magnetic field
- Used to initialize and read spin
- $B = 1.3 \text{ T} \rightarrow E_z \sim 1.7 \text{ K}$

J. M. Elzermann *et al.*, Nature **430**, 431 (2004)

A. Morello *et al.*, Nature **467**, 687 (2010)

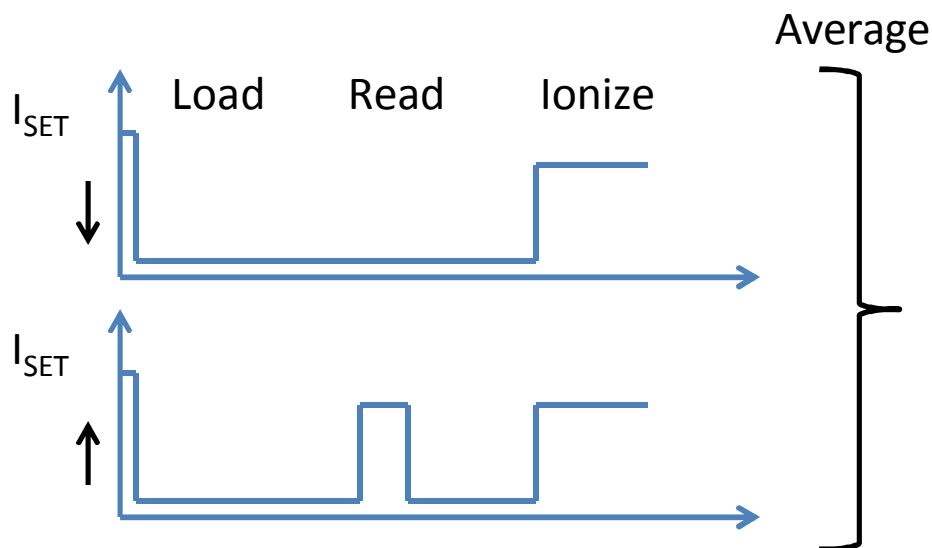


Tuning read level

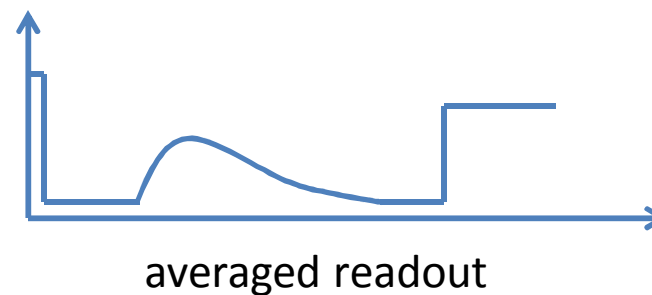


$$\Gamma_{\downarrow l} = 15.1 \pm 0.7 \text{ kHz}$$

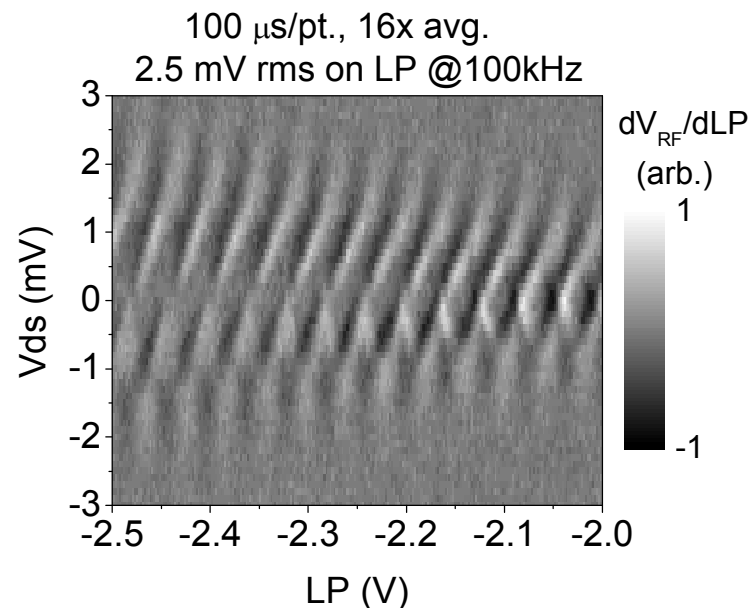
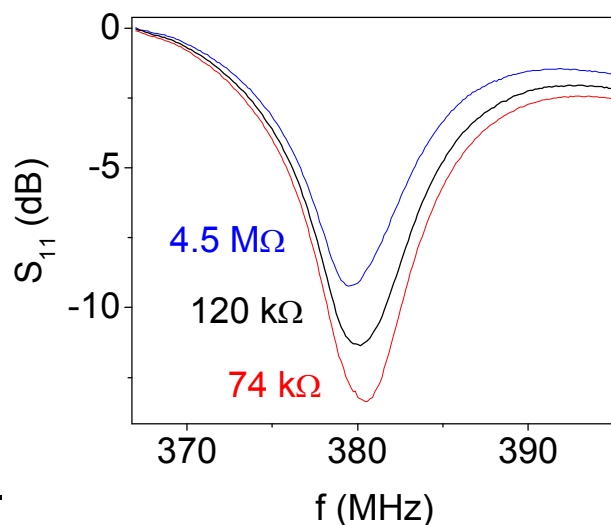
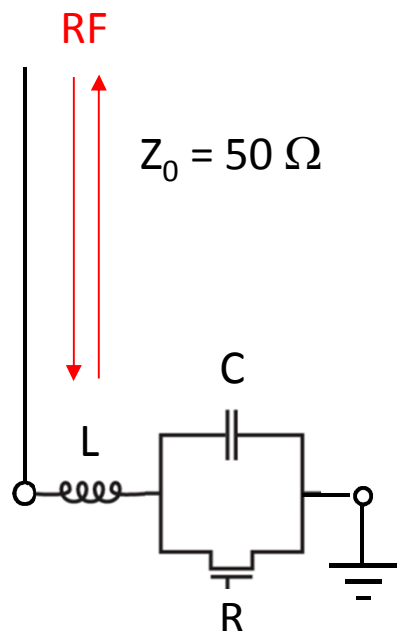
$$\Gamma_{\uparrow u} = 6.8 \pm 0.2 \text{ kHz}$$



BW for high fidelity single shot readout?

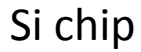


RF Reflectometry



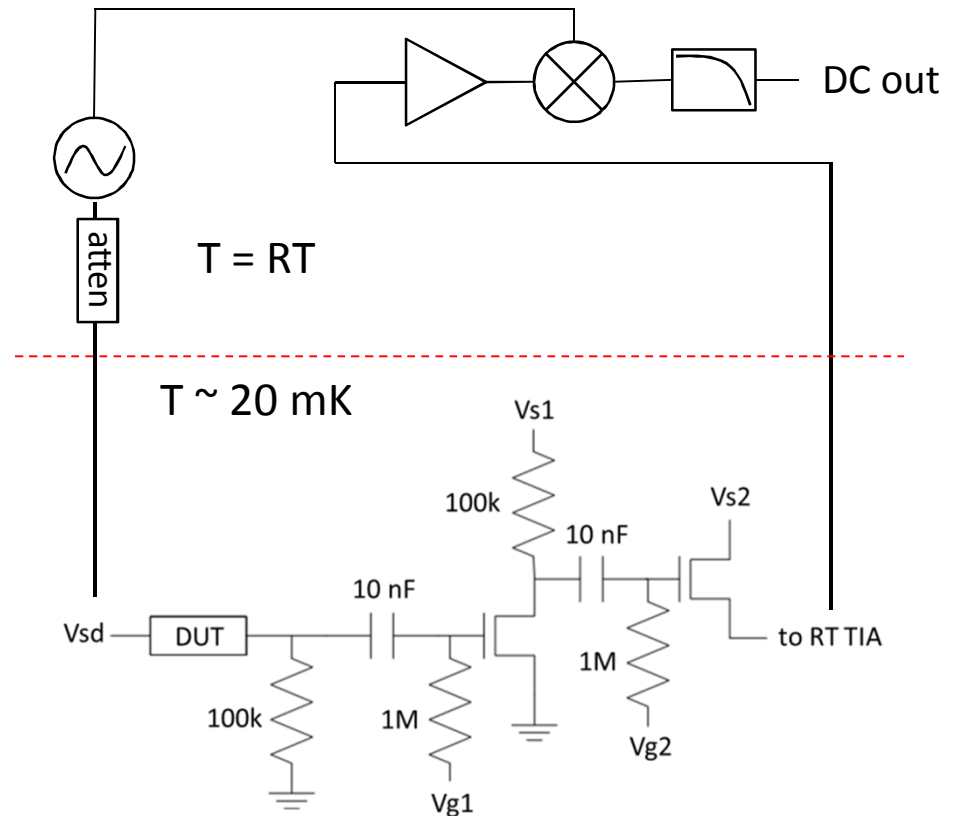
- Si MOS RF SET: 10 MHz BW and $\sim 10^{-9} \Omega^{-1} / \text{VHz}$ sensitivity and for $V_{sd} \sim 200 \mu\text{V}$
- Corresponds to noise $\sim 200 \text{ fA Hz}^{-1/2}$
- Other groups have achieved $\sim 100 \text{ fA Hz}^{-1/2}$ (Reilley *et al.*, Phys. Rev. Lett. (2007))

Schoelkopf et al., Science 1998

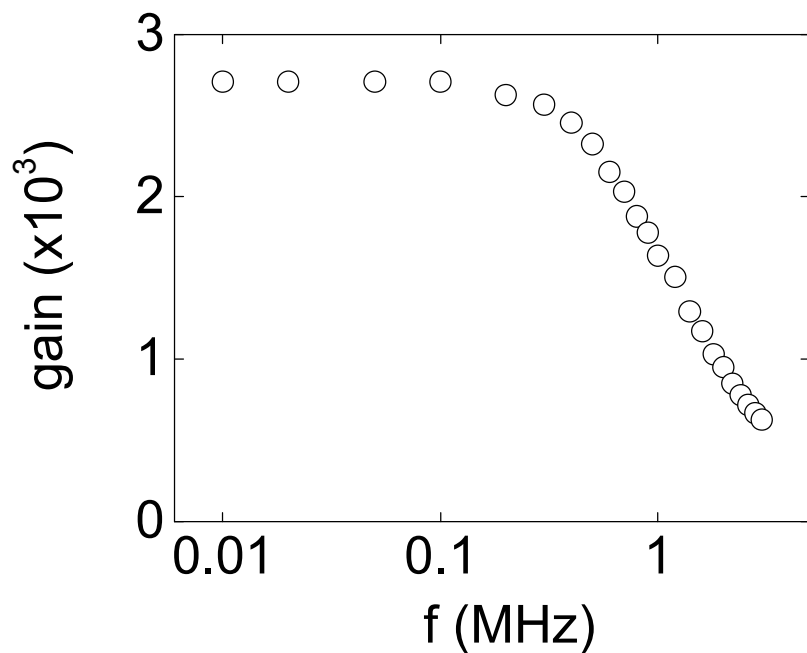


HEMT circuit

- Commercial InGaAs enhancement mode HEMTs

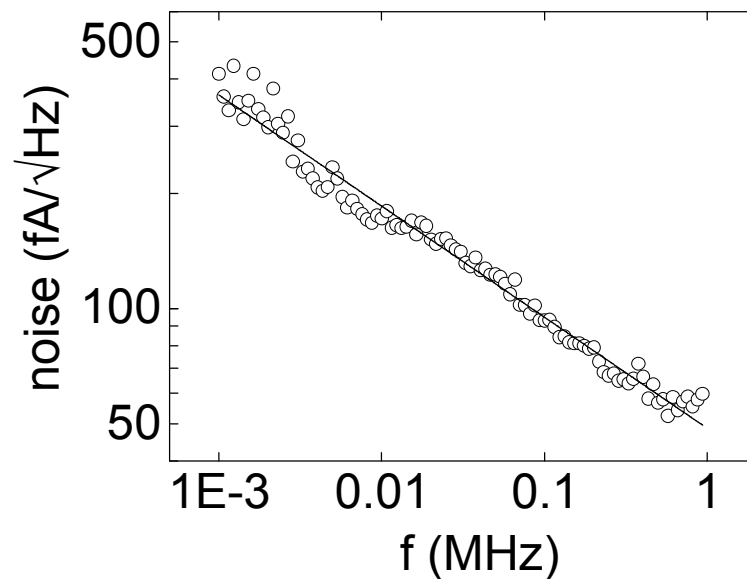
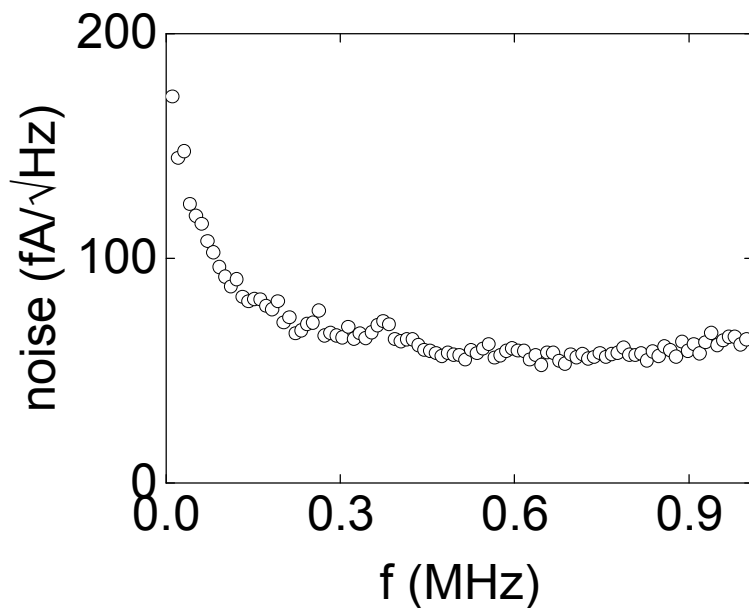


Gain and bandwidth



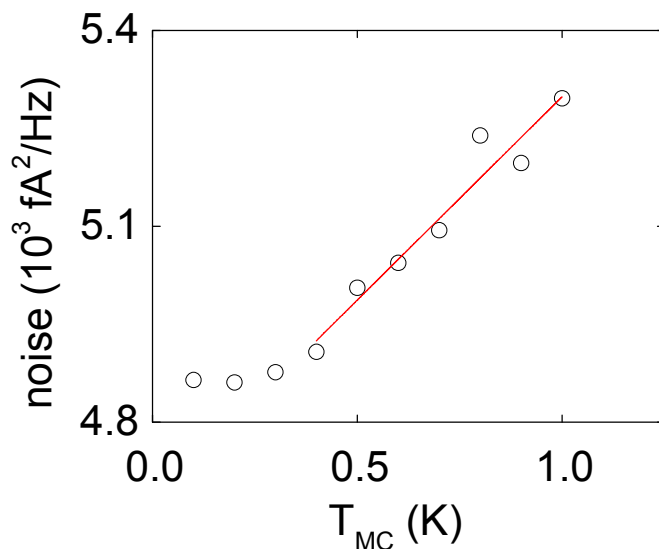
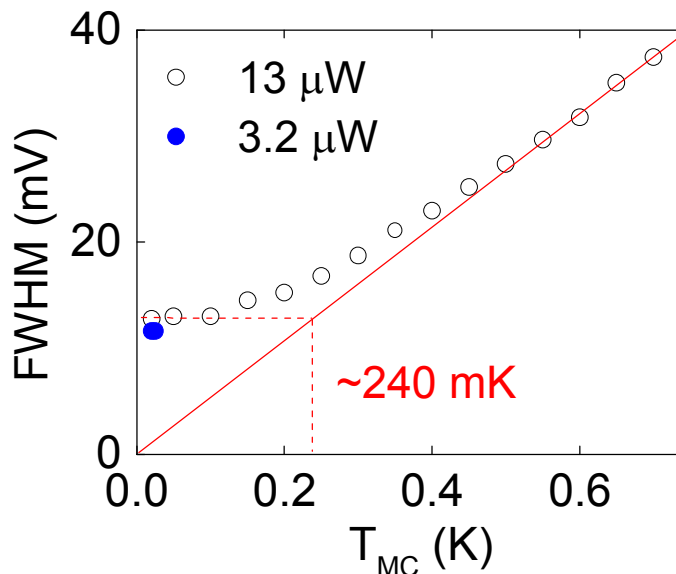
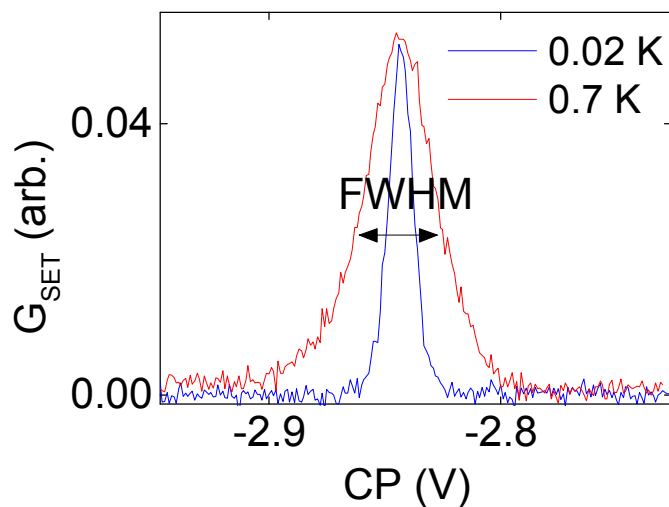
- DUT = 100k resistor
- Meas BW ~ 1.3 MHz
- 1st HEMT: 3 μ W, 2nd HEMT 10 μ W
 $\rightarrow$ 13 μ W total
- tradeoff gain for power?

Noise



- $\sim 70 \text{ fA Hz}^{-1/2}$ above 0.3 MHz
- $1/f$ noise ($\sim f^{-0.3}$)

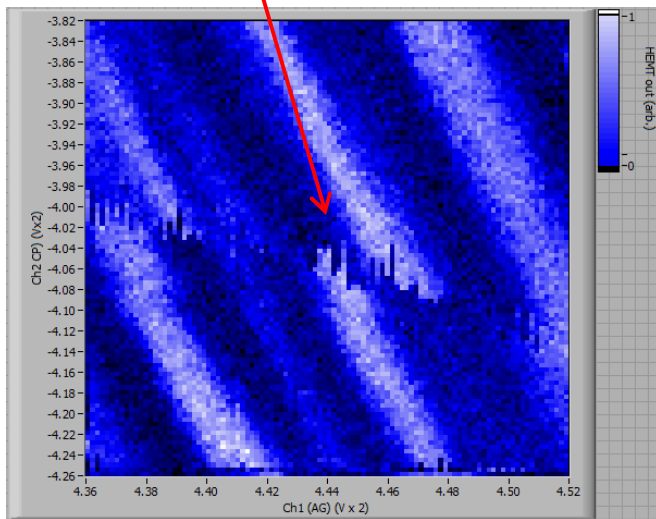
Temperature



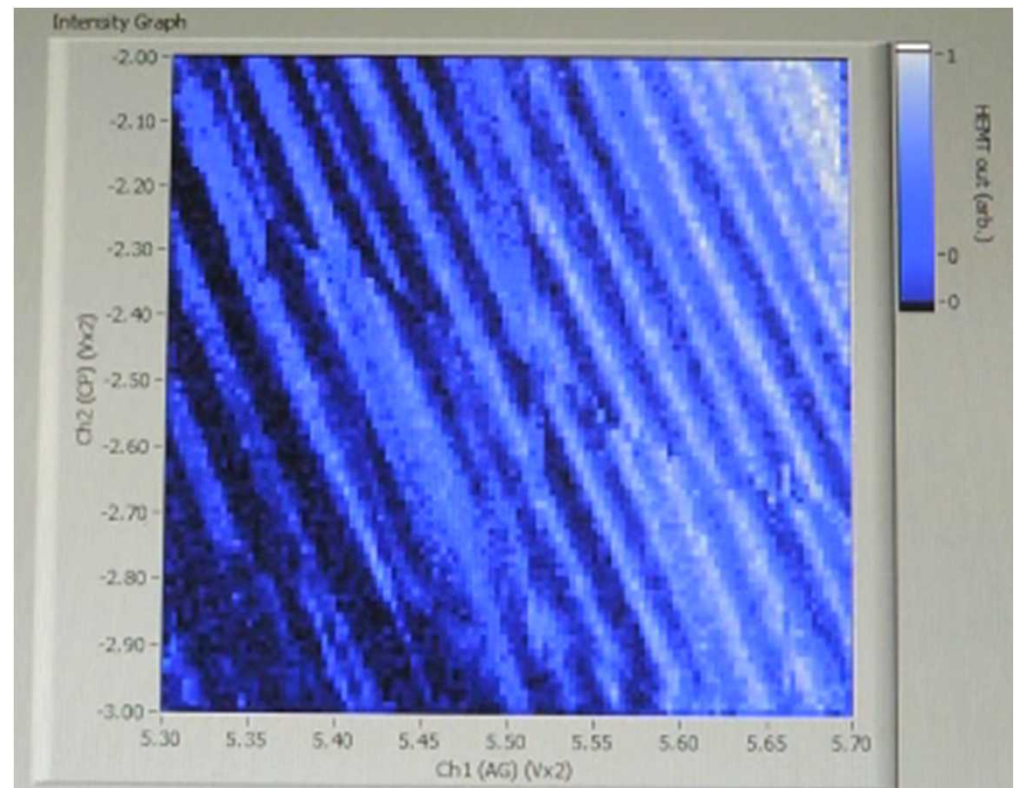
- SET temperature ~ 240 mK at $13 \mu\text{W}$
- ~ 220 mK at $3 \mu\text{W}$ suggests not dominated by HEMT
- Slope of noise vs. T_{MC} greater than expected for simple Johnson noise
- Knee of noise vs. T_{MC} suggests 1st HEMT ~ 300 mK

Live SET tuning

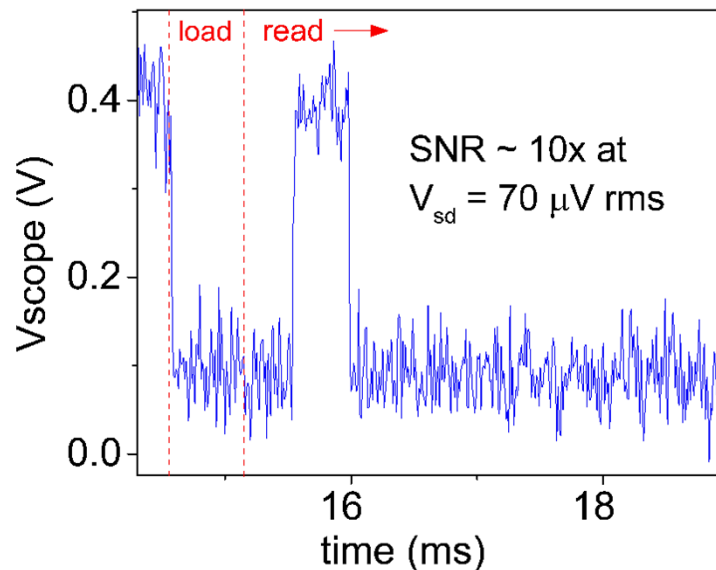
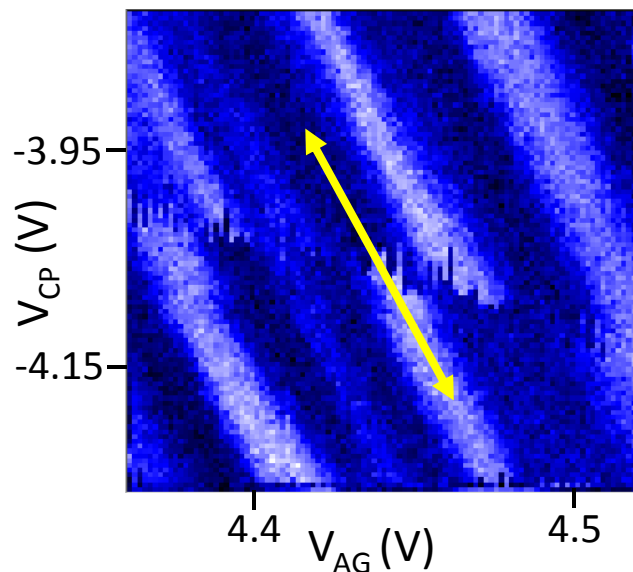
- Rapid search for donor charge transitions
- Response rate of offset gives tunnel time estimate



100 x 100 scan, ~3 Hz refresh rate

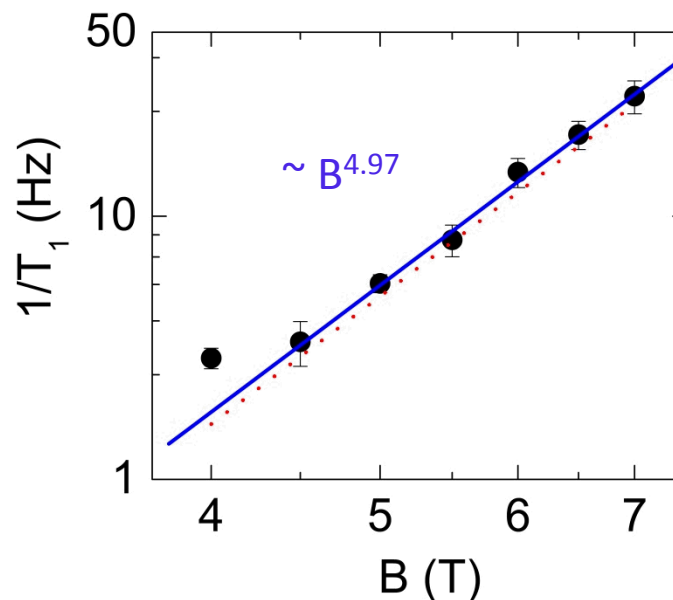
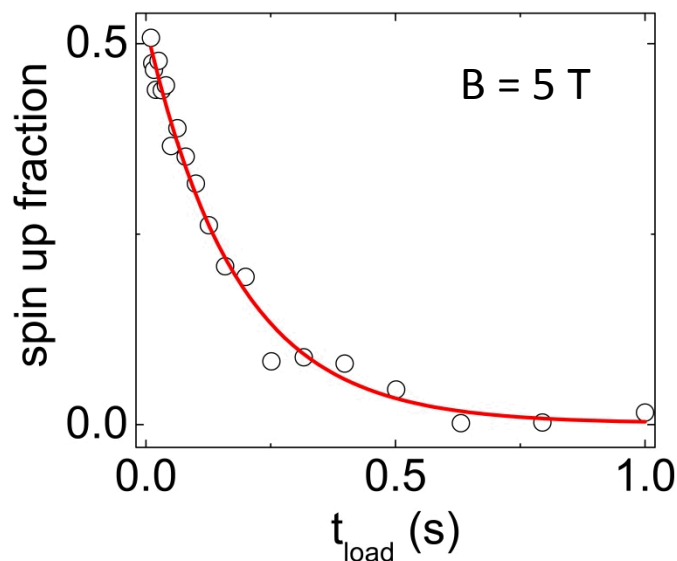


Single shot spin readout



- Single shot event SNR $\sim 10x$ for $V_{sd} = 70 \mu V$ rms
- Effect of dry fridge triboelectric noise reduced by gain before coax and by working at higher frequencies

Magnetic field dependence of T_1 (Sb donor)



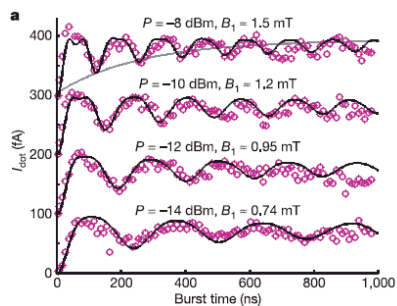
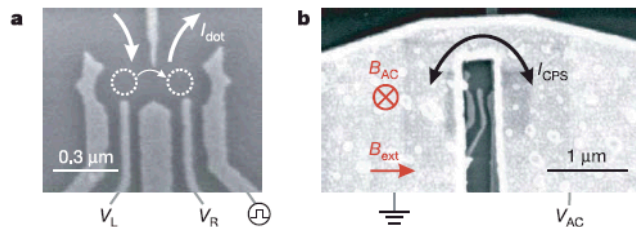
- Expect $T_1 \sim B^5$ for donor spins, due to g-factor dependence on strain (L. Roth, Phys. Rev. (1960), H. Hasegawa, Phys. Rev. (1960))
- Red dotted line expected T_1 extrapolated from bulk ESR meas (D. K. Wilson and G. Feher, Phys. Rev. (1961))
- $T_1 \sim 350$ ms at low fields, may be due to dipolar interactions with neighboring Sb electron spins ($\sim 10^{17}/\text{cm}^3$) (Morello *et al.*, Nature (2010))
- $T_1 \geq 350$ ms at $B = 1.3$ T

Tracy *et al.*, Appl. Phys. Lett. (2013)

Local ESR & NMR

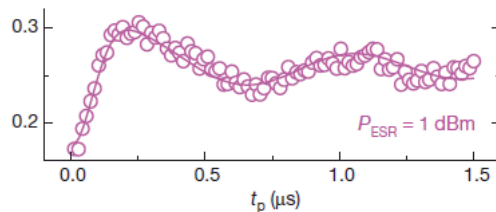
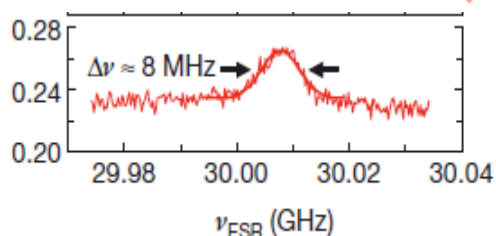
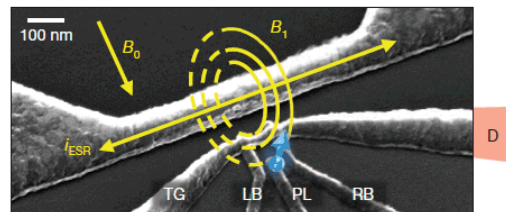
- Can use local RF and microwave magnetic fields to manipulate electron or nuclear spin on a quantum dot or donor
- Extract T_2 , perform single qubit operations

ESR with GaAs quantum dot

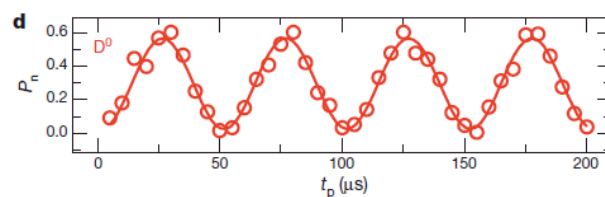
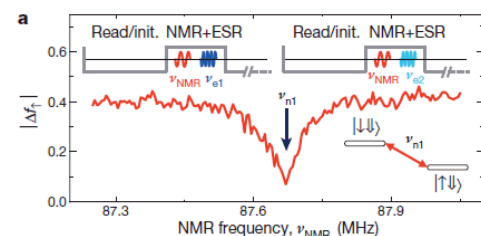


F. H. L. Koppens et al., Nature (2006)

ESR & NMR with single donor in Si



J. Pla et al., Nature (2012)



J. J. Pla et al., Nature (2013).

Electron spin resonance with P donor in Si

Zeeman splitting

For electron:

$$E_Z = g \mu_B B_z, g = -1.9985$$

At 1 Tesla

$$E_Z = 1.34 \text{ K} = 28 \text{ GHz}$$

For nuclear spin:

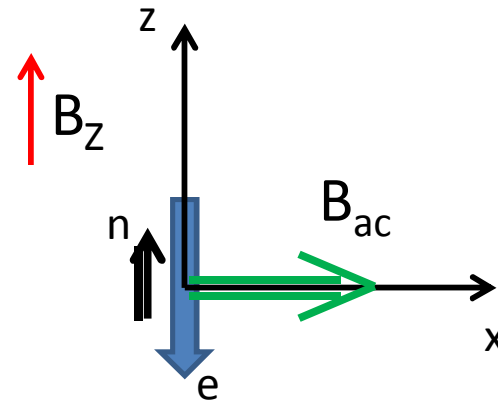
At 1 Tesla

$$E_Z = 0.8 \text{ mK} = 17.2 \text{ MHz}$$

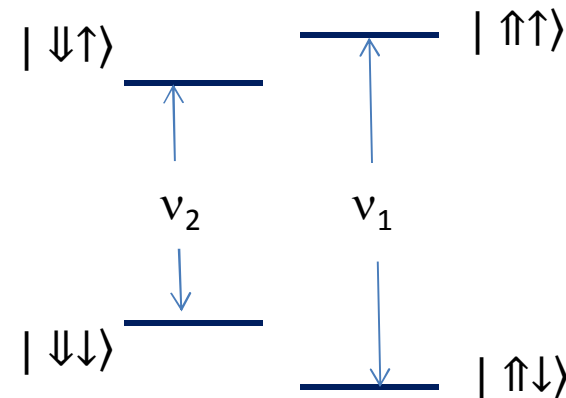
With hyperfine coupling

$$H = \gamma_e B_0 S_z - \gamma_N B_0 I_z + A S \cdot I$$

$$A = 117 \text{ MHz for P}$$

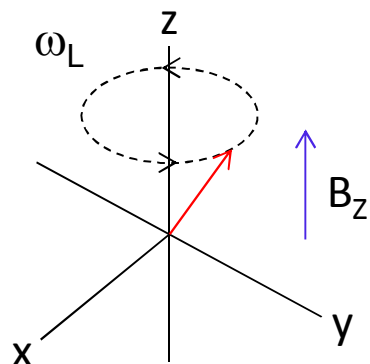


ESR transitions

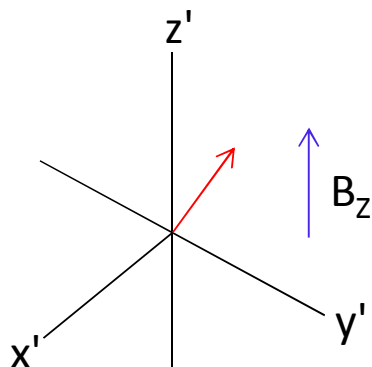


Coherence times T_2^* , T_2

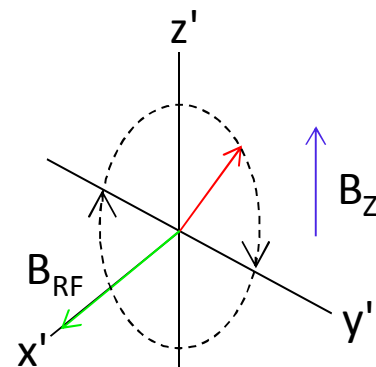
Larmor precession



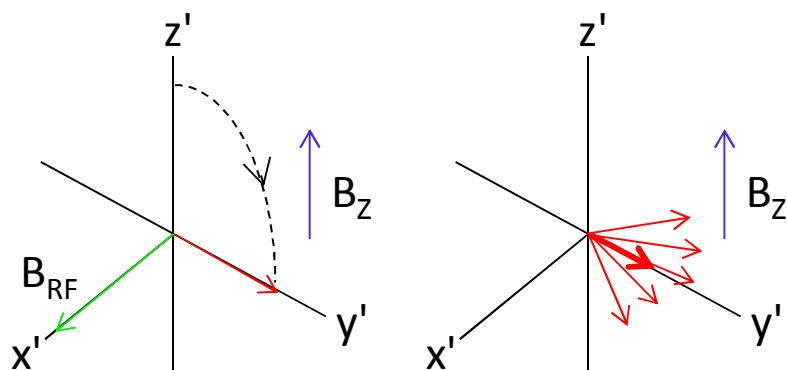
Rotating frame



Rabi oscillations

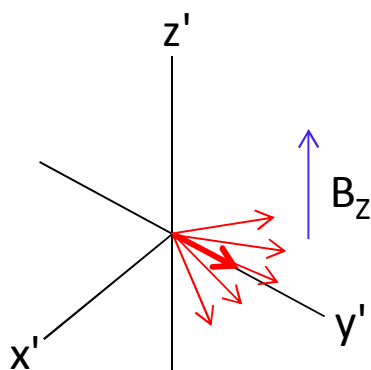


T_2^* dephasing

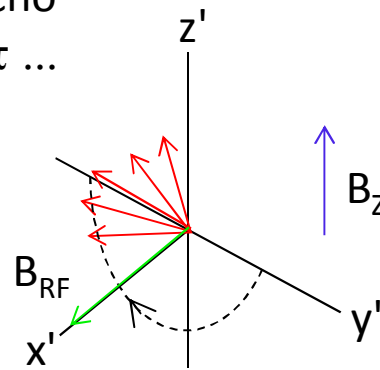


$\pi/2$ pulse

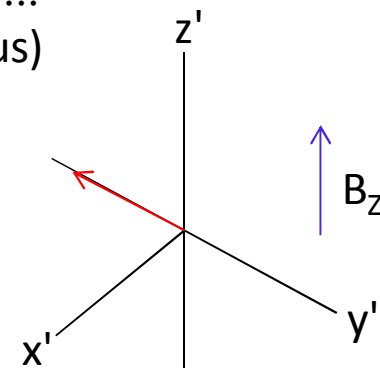
for echo
wait τ ...



wait τ ...
(refocus)

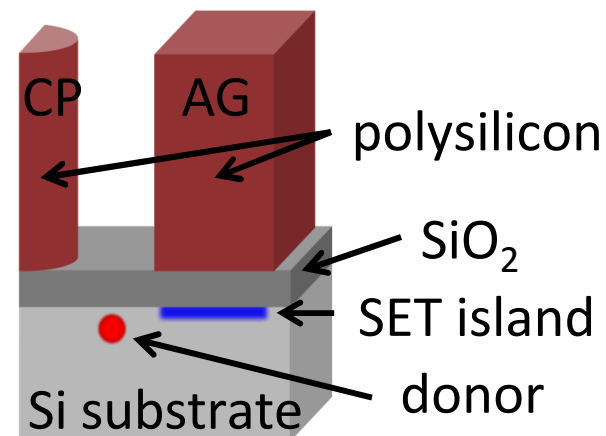
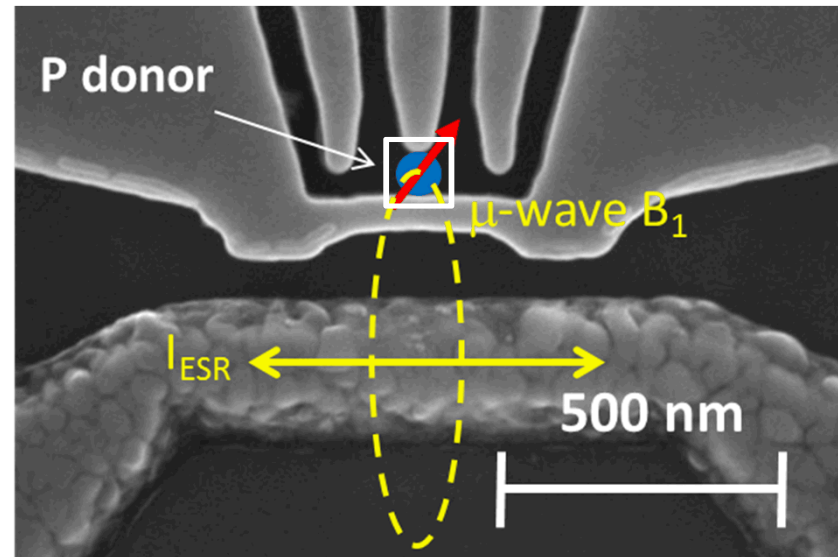


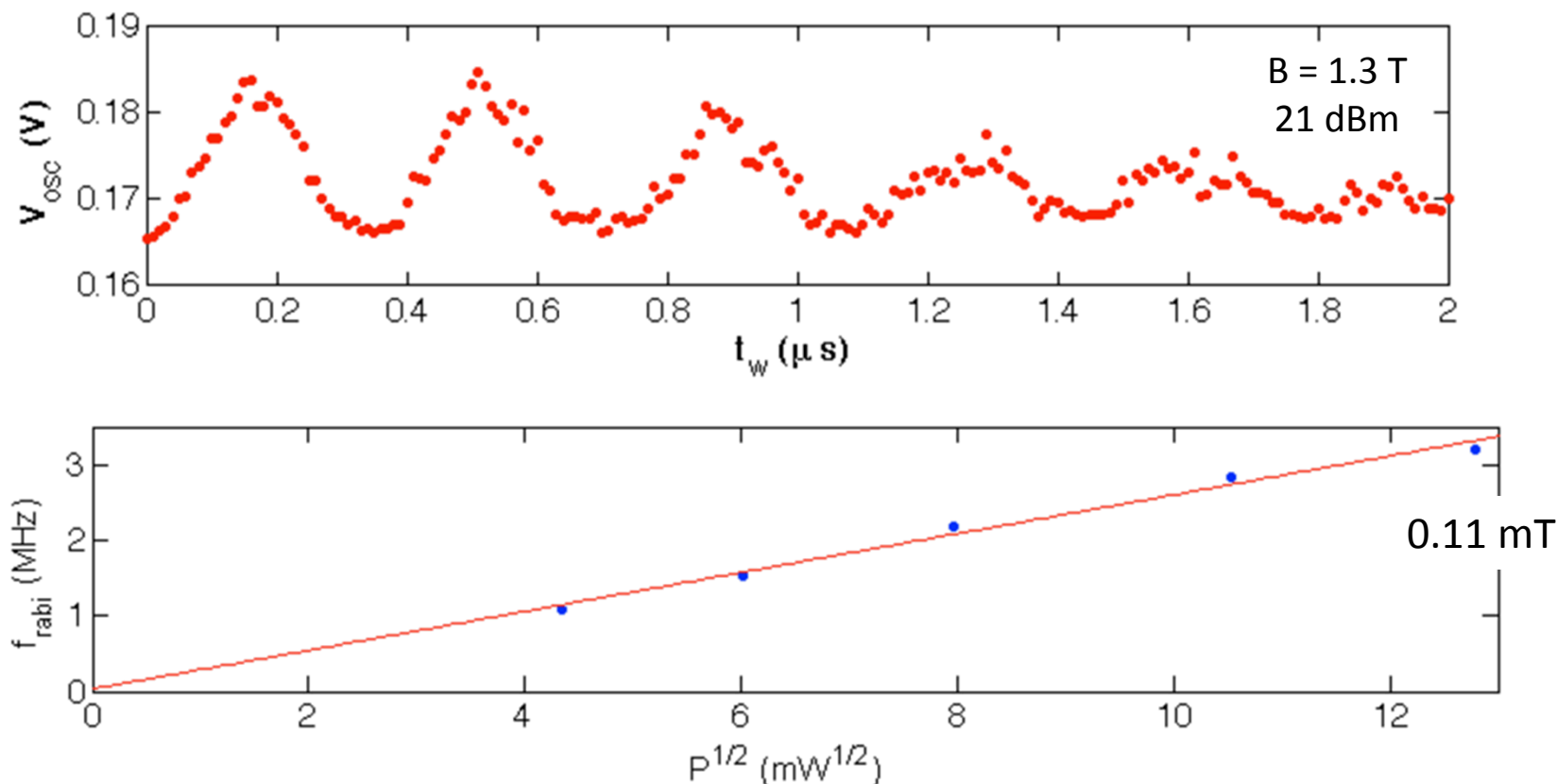
π pulse



local ESR device

- Timed P implant with PMMA window, self-aligned with polysilicon gates
- 45 keV implant, range ~ 15 nm below SiO_2/Si interface
- $4 - 8 \times 10^{11}/\text{cm}^2$ dose
 $\rightarrow \sim 40 - 80$ P donors in $100 \times 100 \text{ nm}^2$ window
- Nearby microwave antenna for local ESR
- Dry dilution refrigerator
 $T_{\text{base}} = 10 - 20 \text{ mK}$
 $T_{\text{electron}} = 200 - 300 \text{ mK}$

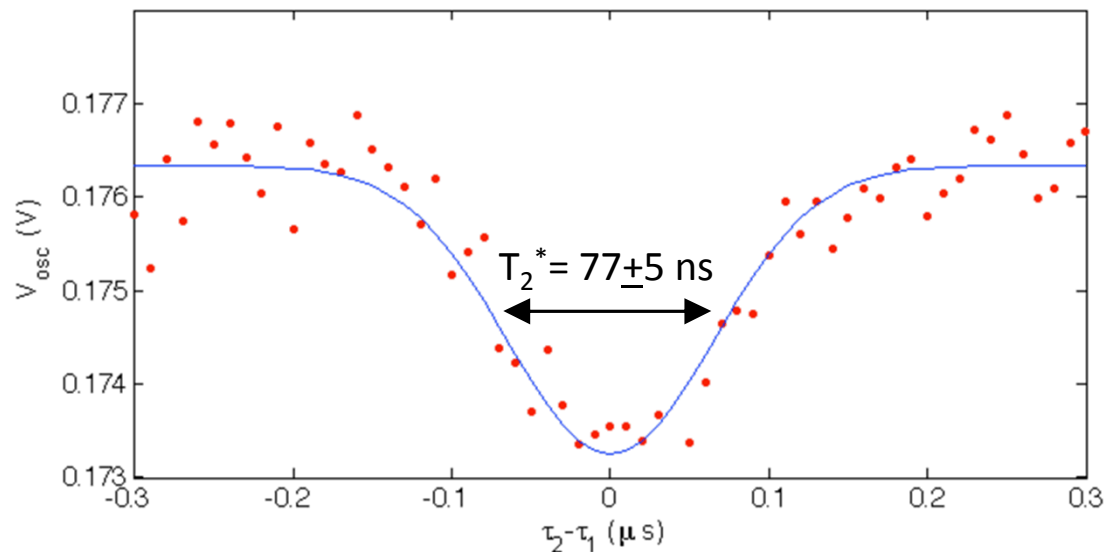
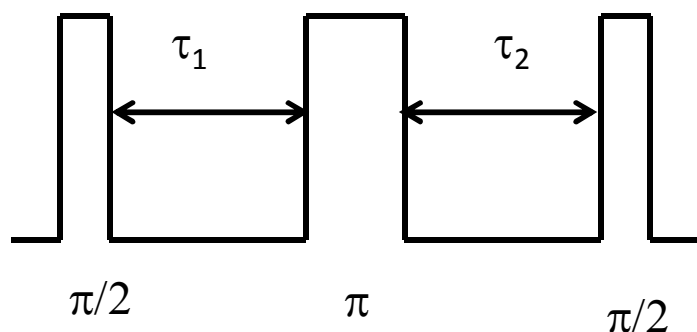




- Pre-HEMT implementation, dry fridge noise prevents single shot spin meas
- $f_{B1} \sim 36$ GHz @ $B = 1.3$ T
- Rabi frequency linear in B_1

Spin echo technique:

Vary τ_2 relative to $\tau_1 = 10 \mu\text{s}$

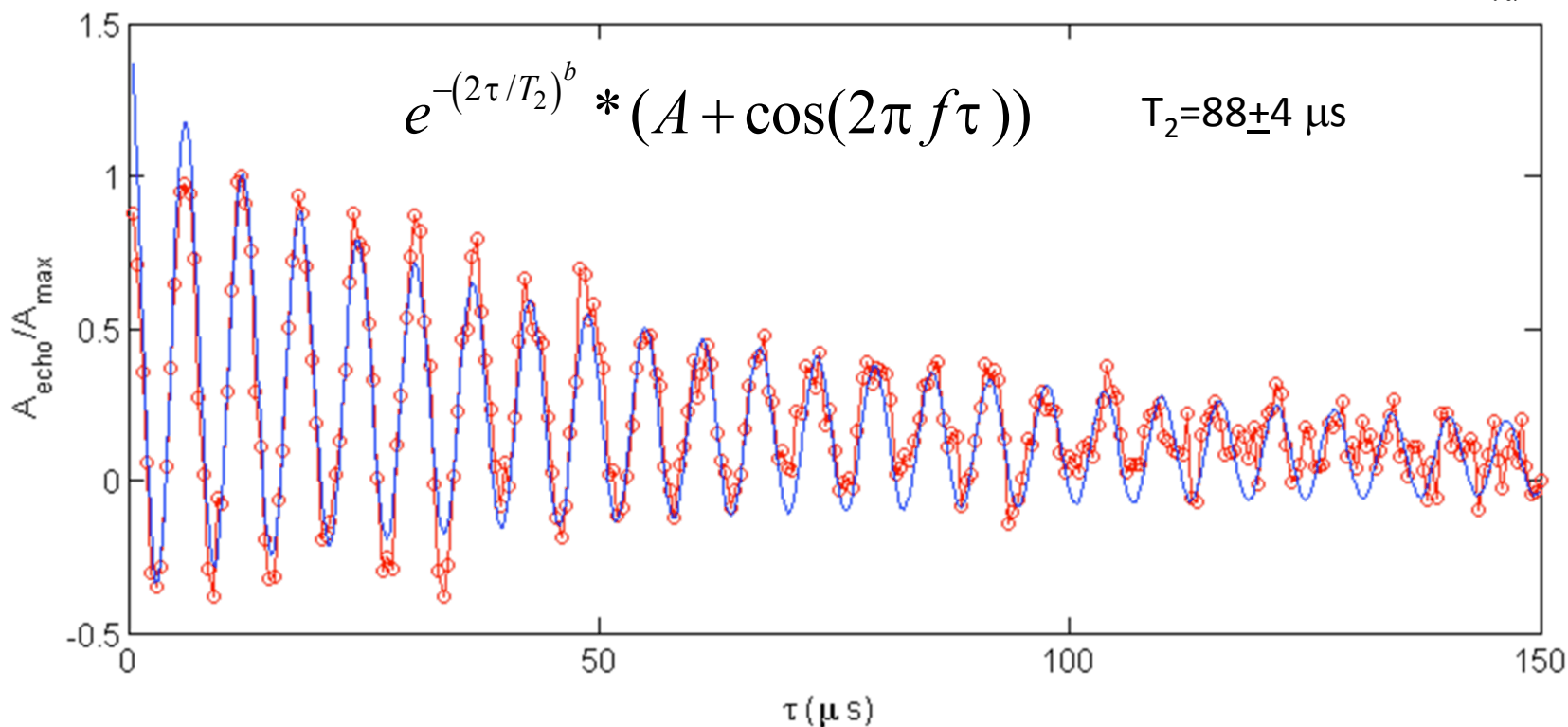
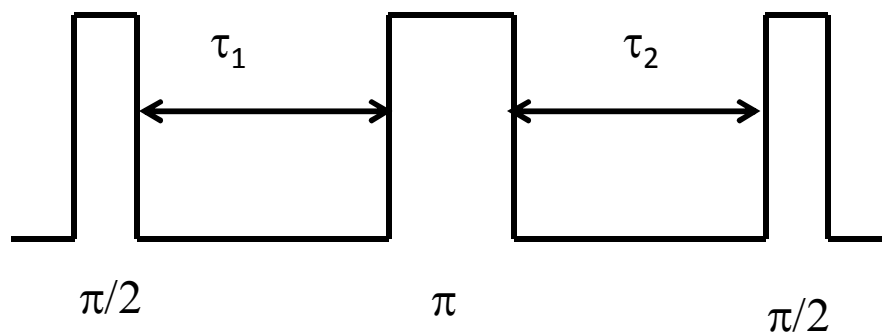


- $T_2^* = 77 \text{ ns}$, consistent with ESR linewidth (FWHM) = 3.9 MHz
- Intrinsic control fidelity = 62%
- Similar to previous meas on nat. Si, $T_2^* = 55 \text{ ns}$ (J. J. Pla *et al.*, Nature (2012))

T₂ Measurement

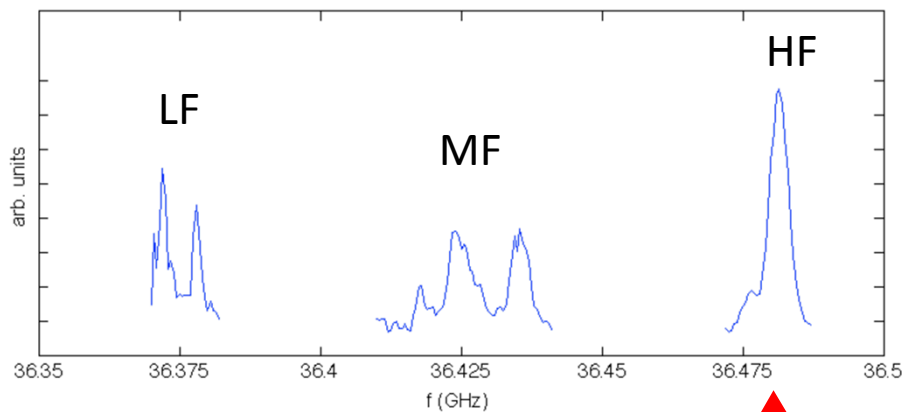
D. R. Luhman

Hahn Echo with $\tau_1 = \tau_2$:
Vary τ



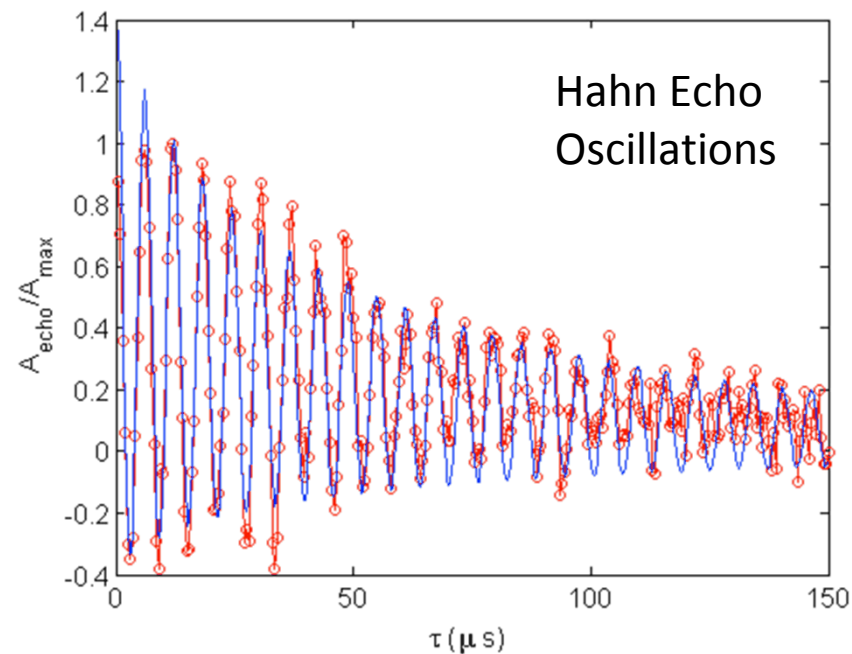
Unexpected Features

ESR line shape



used for ESR

Hahn Echo Oscillations

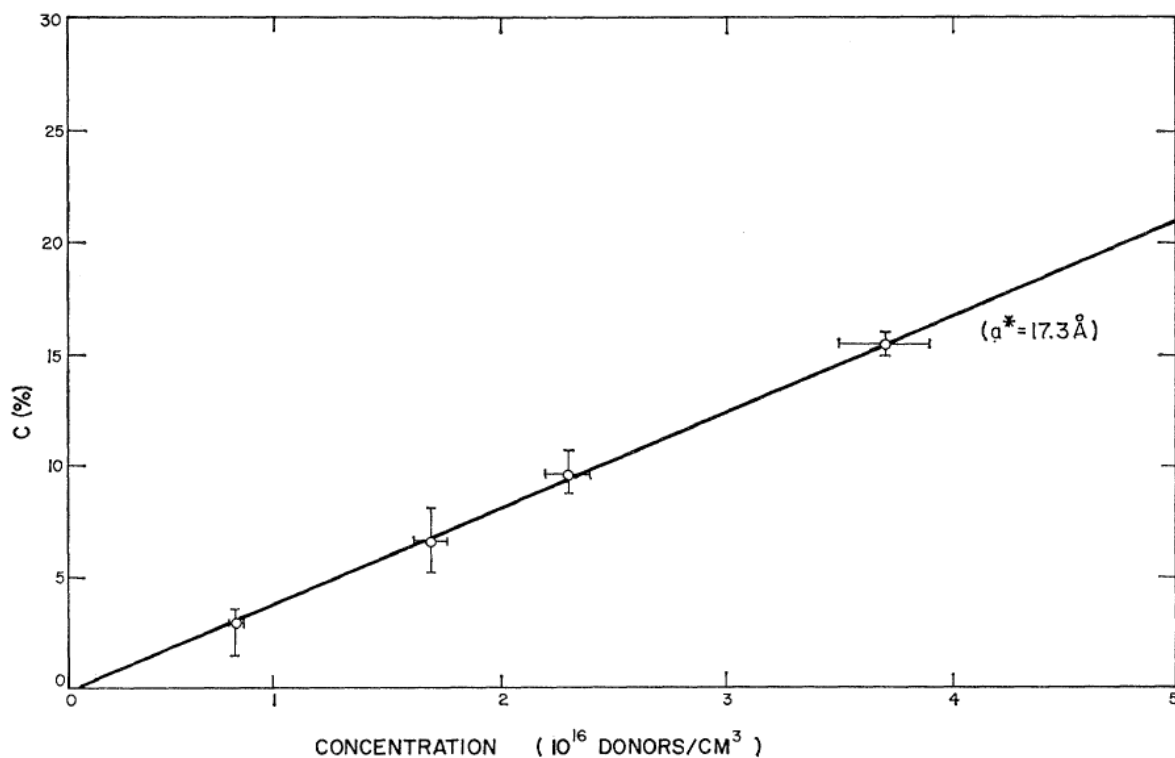


Possible explanation: P_2 Dimer

- Implant density high ($8 \times 10^{11}/\text{cm}^2$)
- For $J \gg A$, a center line is expected

Dimers in bulk P doped Si

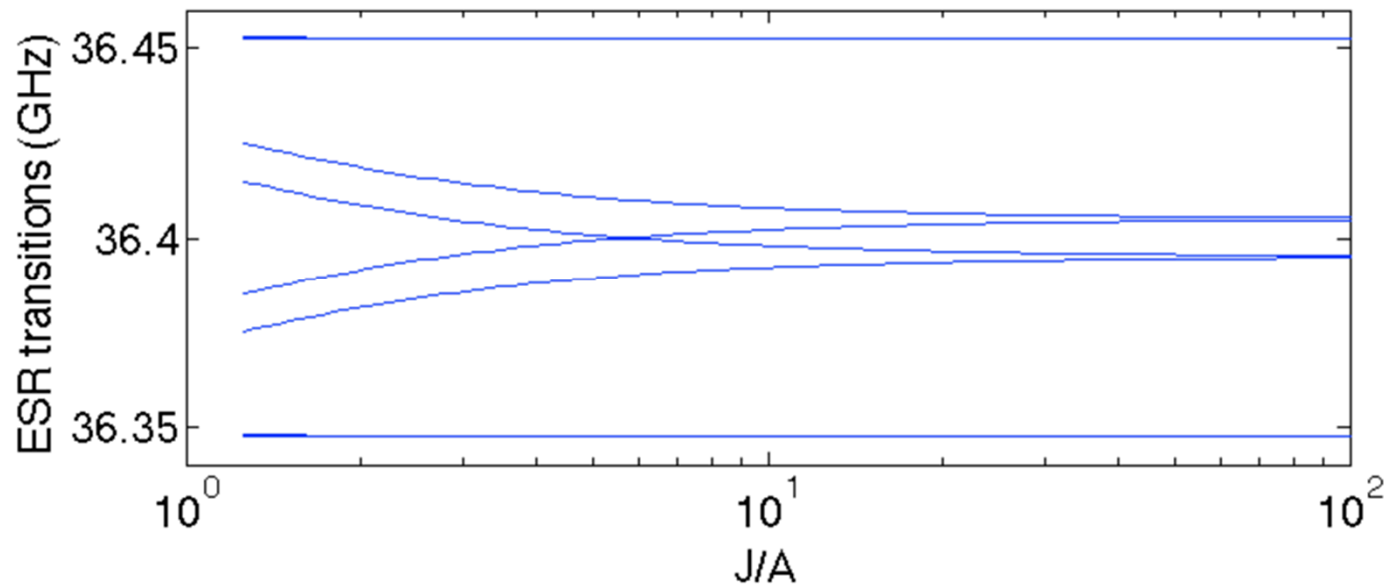
Cullis and Marko, 1970
exchange effects in P doped Si



Ratio of the center line compared to outer lines
for different P density. For the ESR device, the
local implant density is $\sim 1 \times 10^{17} \text{ cm}^{-3}$

P2 Model for ESR data

$$H = \nu_e B + \nu_n B + J(S_1 \cdot S_2) + A_1(S_1 \cdot I_1) + A_2(S_2 \cdot I_2)$$



$\Delta A = 14\text{-}24$ MHz

$J/A \sim 2.5\text{-}4$

$\Delta f \sim 165$ kHz and independent of B

Consistent with experiment

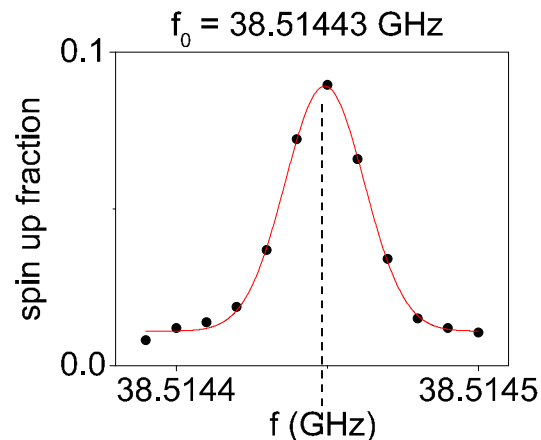
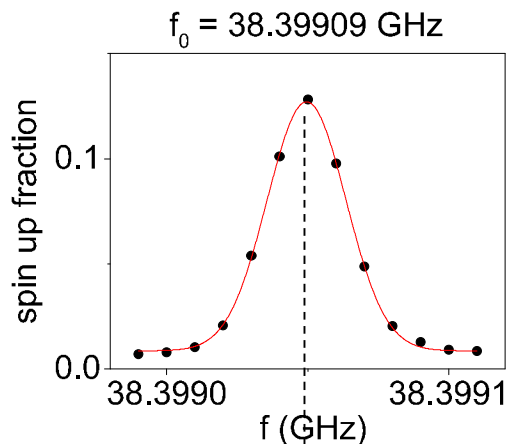
Enriched ^{28}Si : P donor ESR line

^{28}Si epilayer

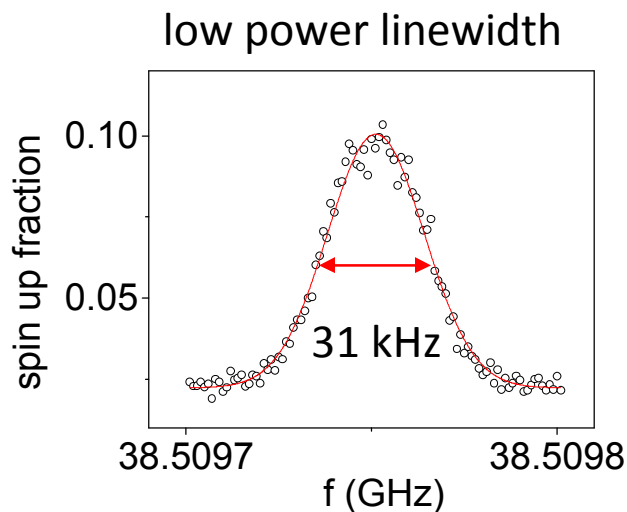
- 2.5 μm thick
- 500 ppm ^{29}Si (ToF SIMS)

P Implant

- 45 keV implant
- range ~ 15 nm below SiO_2/Si interface
- Fluence: $4 \times 10^{11} \text{ cm}^{-2}$

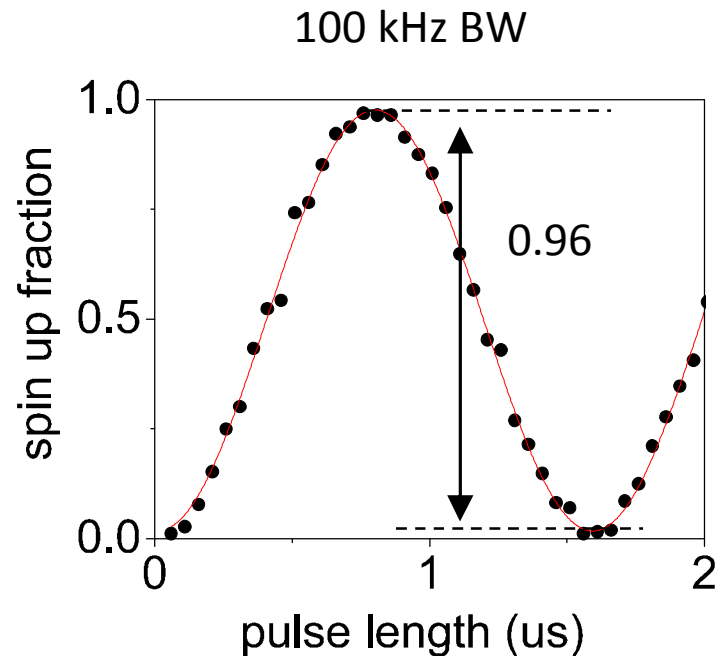
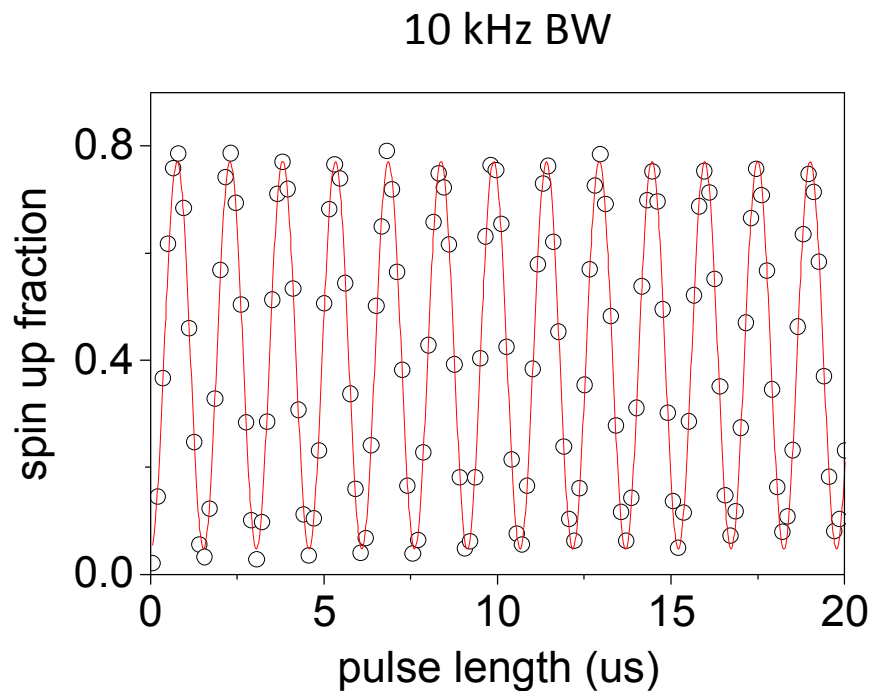


P hyperfine: $\Delta f_0 = 115.3 \text{ MHz}$



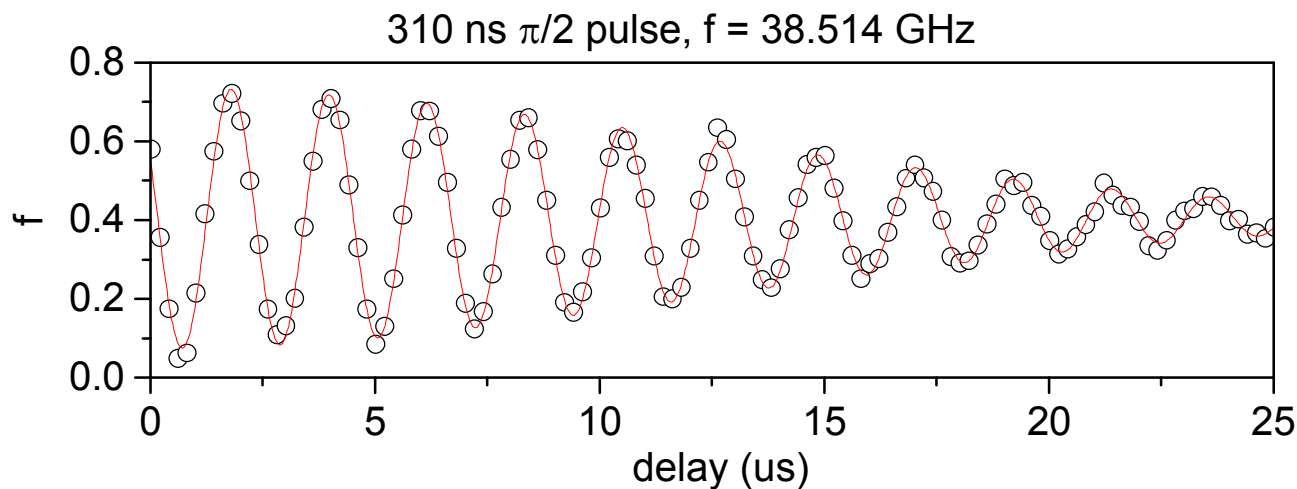
- Similar lines seen in two ^{28}Si ESR devices (115 – 116 MHz hyperfine w/ ~ 30 kHz linewidth)
- $\text{FWHM} = 31 \text{ kHz} \rightarrow T_2^* = 10 \text{ us}$

Rabi oscillations

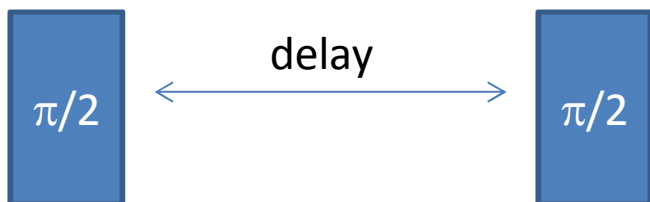


- Long lived Rabi oscillations
- Visibility reduced because readout BW was not optimized (~ 10 kHz)
For example, fast spin-up tunneling events can be missed.
- Visibility $\sim 96\%$ (readout & initialization)

Ramsey fringes

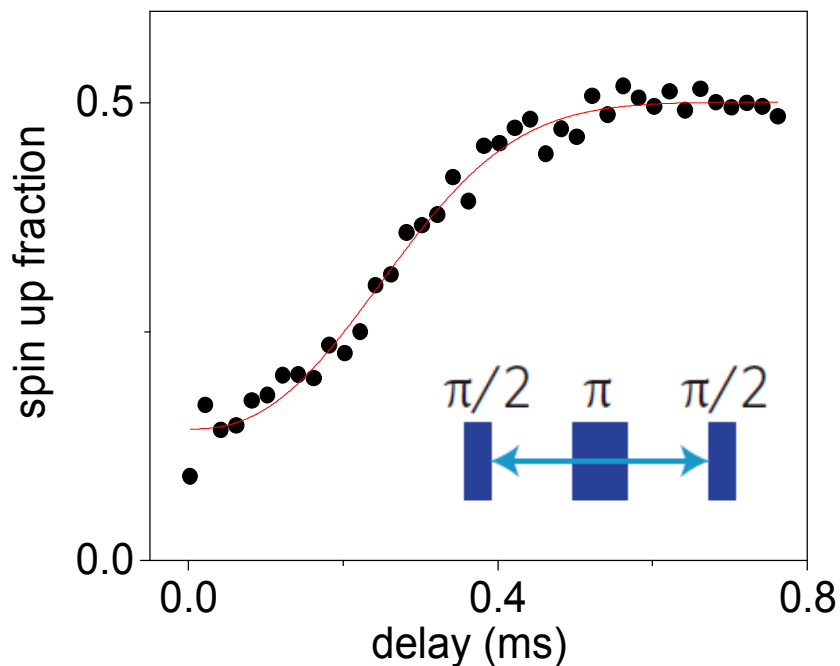


Fit envelope: $f = P_0 \exp[-(t/T_2^*)^2] + P_\infty$
 $\rightarrow T_2^* \sim 18$ us



- ~ 0.5 MHz detuning from resonance
- T_2^* value in same ballpark as linewidth estimate, but slightly longer (~ 18 us vs. 10 us)
- Intrinsic control fidelity $\sim 99.99\%$

Hahn Echo



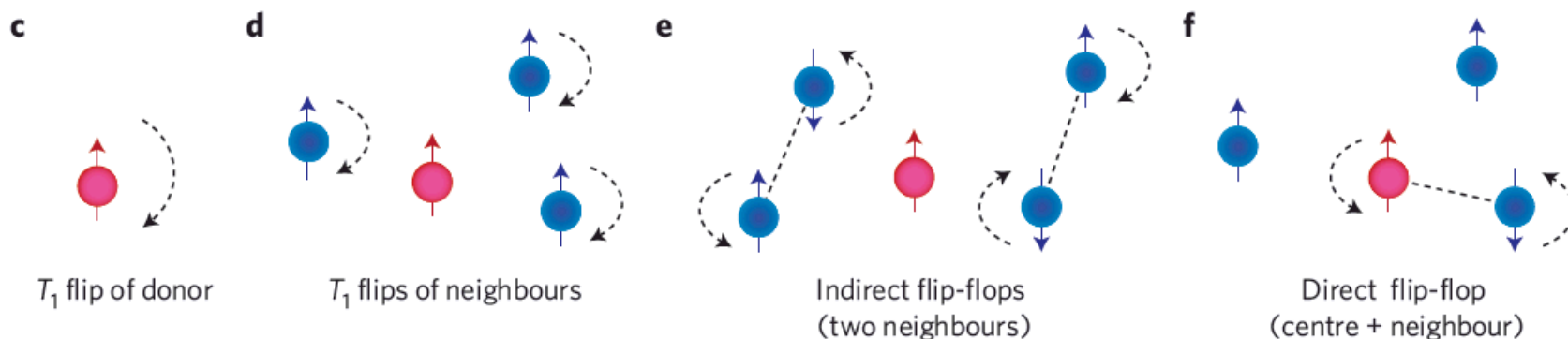
- Echo T_2 in ballpark of previous meas of 0.95 ms, $n = 3.5$ (J. T. Muhonen et al., Nature Nano (2012))
- Exponent $n = 2.4$, for $1/f$ noise $n = 2$

Fit: $f = P_0 \exp[-(t/T_2)^n] + P_\infty$
 $\rightarrow T_2 = 0.31 \text{ ms}, n = 2.4$

Limiting factors for line width and T_2

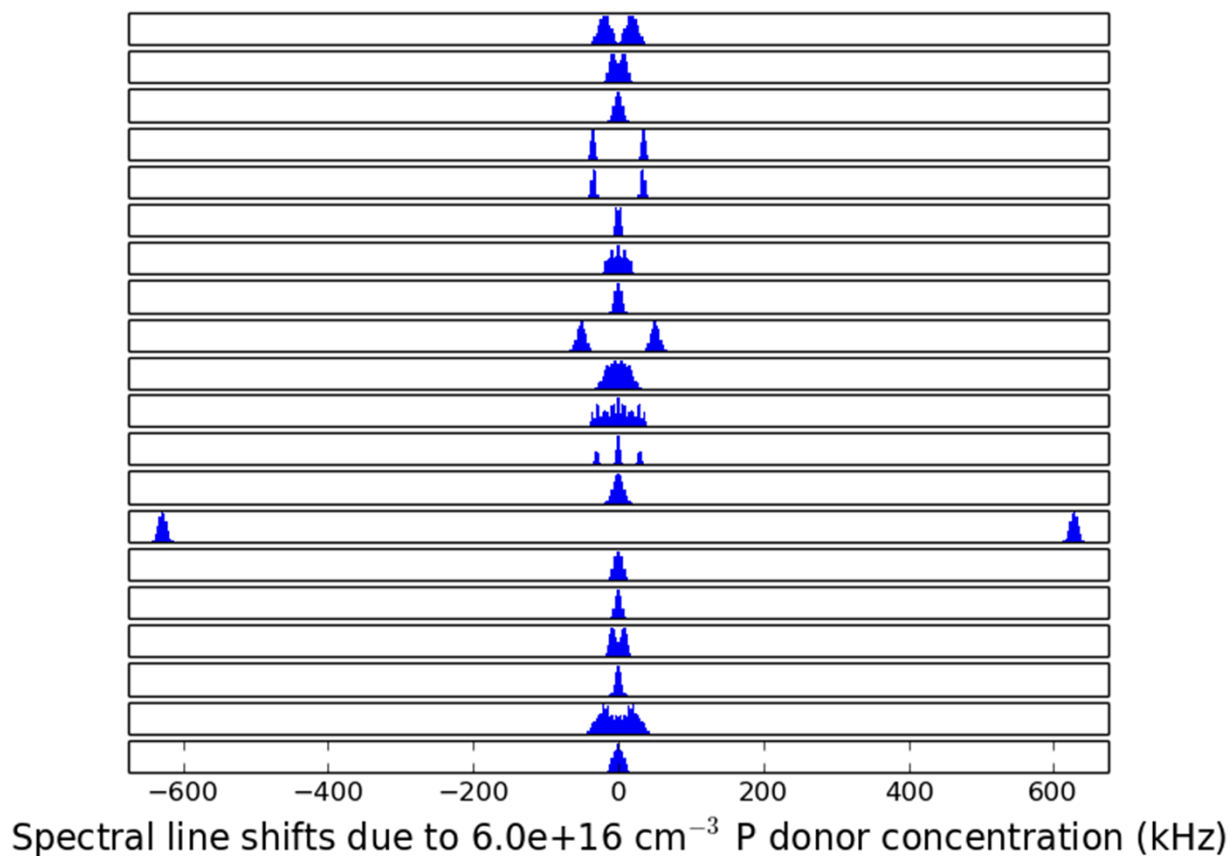
- Observed ~ 30 kHz ESR line width in two samples
- $T_2^* = 18$ μs shorter than meas $T_2^* = 270$ μs of J. T. Muhonen *et al.*, Nat. Nano (2014) in 800 ppm ^{28}Si .
- Hahn echo $T_2 = 0.3$ ms vs. 0.95 ms from J. T. Muhonen *et al.*

Decoherence from nearby P donors?



Tyryshkin *et al.*, Nat. Mat. (2012)

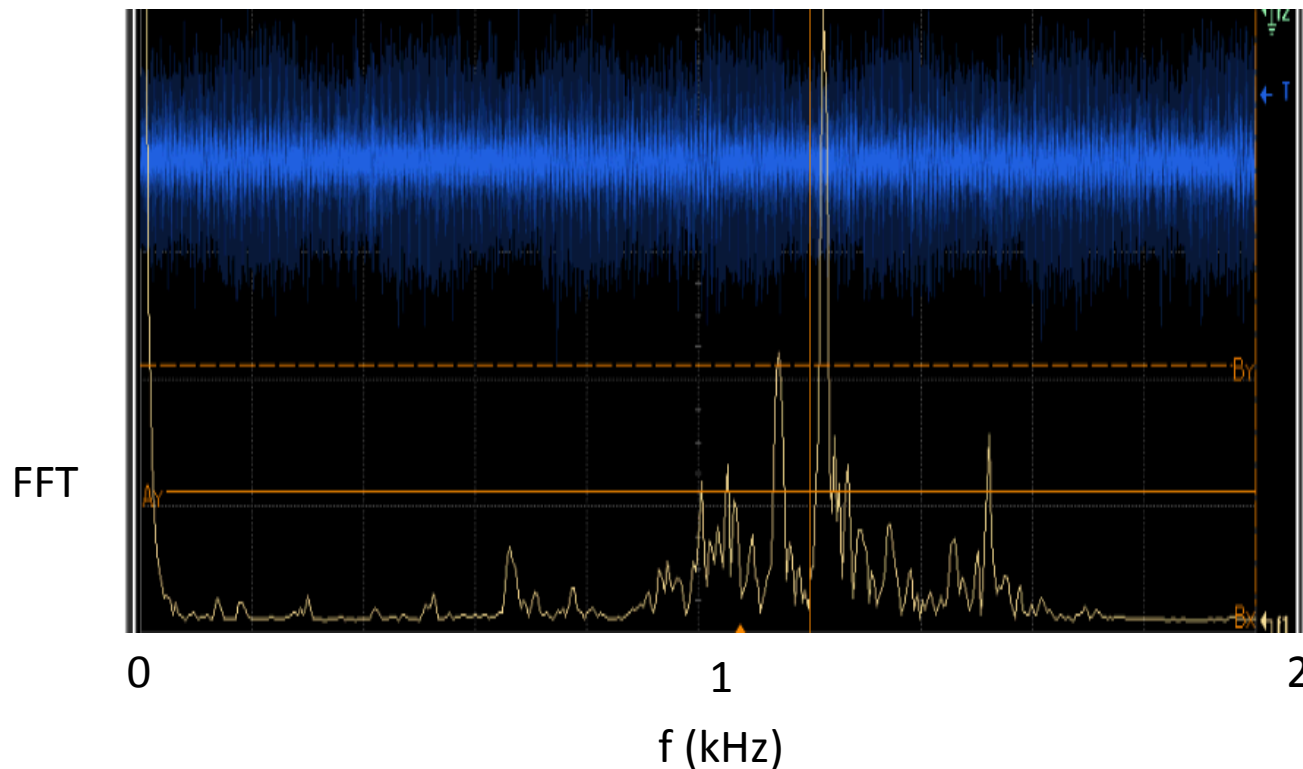
Calculated ESR line shapes



- Each row: different possible spectra for a given constellation of neighboring spins
- Dynamics?

Dilution refrigerator acoustic noise (pulse tube)

Voltage from pickup coil at sample position



Rough estimate: ~ 10 μm of vibration, ~ 100 kHz linewidth

Gate Set Tomography

Operator	Hilbert-Schmidt vector (Pauli basis)	Matrix
ρ_0	$\begin{pmatrix} 0.7206 \\ -0.0168 \\ -0.0185 \\ 0.6741 \end{pmatrix}$	$\begin{pmatrix} 0.9862 & 0.0177e^{i2.3} \\ 0.0177e^{-i2.3} & 0.0328 \end{pmatrix}$
E_0	$\begin{pmatrix} 0.6929 \\ 0.0328 \\ -0.0029 \\ -0.6516 \end{pmatrix}$	$\begin{pmatrix} 0.0292 & 0.0233e^{i0.1} \\ 0.0233e^{-i0.1} & 0.9507 \end{pmatrix}$

Table 5: The GST estimate of the SPAM operations. Compare to Table 1.

Gate	Superoperator (Pauli basis)
G_i	$\begin{pmatrix} 0.9992 & -0.0007 & 0.006 & 0.004 \\ -0.002 & 0.953 & 0.0227 & 0.0008 \\ 0.0114 & -0.0115 & 0.9361 & 0.0065 \\ 0.0027 & -0.0009 & -0.0061 & 1.0047 \end{pmatrix}$
G_x	$\begin{pmatrix} 1.0003 & 0.0087 & -0.0354 & -0.0027 \\ -0.0048 & 0.9352 & 0.1054 & 0.0869 \\ 0.0089 & 0.1197 & -0.0091 & -0.9284 \\ 0.0051 & -0.1363 & 0.9467 & -0.0346 \end{pmatrix}$
G_y	$\begin{pmatrix} 0.999 & 0.0496 & -0.008 & -0.0219 \\ 0.0014 & -0.0115 & 0.099 & 0.9425 \\ -0.0072 & 0.1273 & 0.929 & -0.1308 \\ 0.0145 & -0.9091 & 0.0914 & -0.0356 \end{pmatrix}$

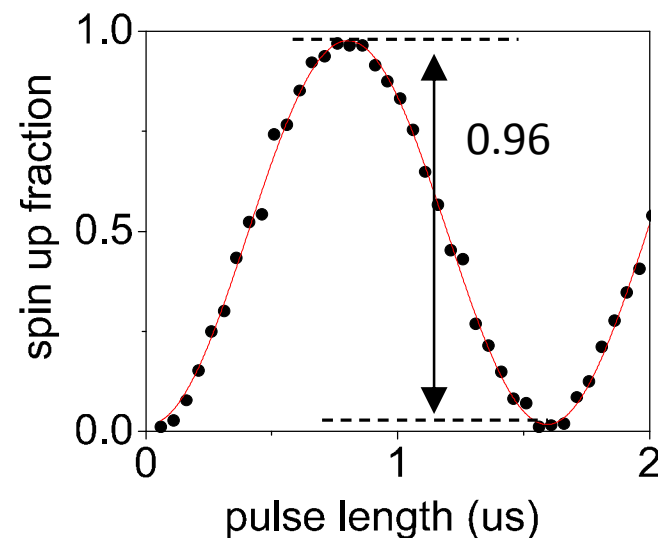
Table 6: The GST estimate of the logic gate operations. Compare to Table 2.

- Gate set tomography (GST) was used to characterize qubit. Maximum length base sequence $L = 8$.
- State preparation and measurement error (SPAM) is $\sim 6\%$
- Idle gate error is $\sim 2.5\%$.
- X and Y rotation errors $\sim 5\%$. Looks like phase error between X and Y. Possibly instrumental error which can be improved.

Conclusions

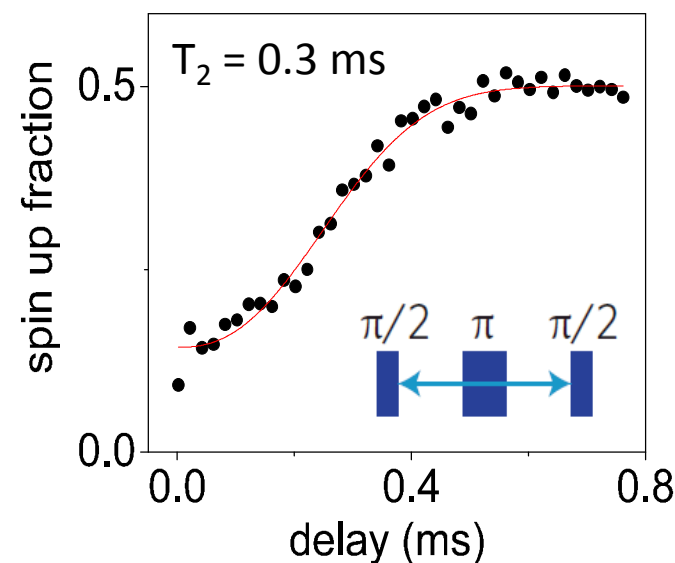
Natural Silicon:

- Three ESR lines (dimer)
- Coherence
 - $T_2^* = 77$ ns
 - $T_2 = 88$ μ s (Hahn Echo)



Enriched ^{28}Si (500 ppm):

- Two ESR lines
- Control Fidelity 95% (GST)
- Rabi Visibility 96%
- Coherence
 - $T_2^* = 18$ μ s
 - $T_2 = 0.3$ ms (Hahn Echo)



Acknowledgements

- QIST contributors at SNL

Qubit fab: M. Busse, J. Dominguez, T. Pluym, B. Silva, G. Ten Eyck, J. Wendt, S. Wolfley

Qubit Measurement: N. Bishop, S. Carr, S. Eley, M. Lilly, T.-M. Lu, D. Luhman, K. Nguyen, M. Rudolph, M. Singh, L. Tracy, M. Wanke

Advanced fabrication (two qubit): E. Bielejec, E. Bussmann, A. MacDonald, B. McWatters, S. Misra, D. Perry, D. Serkland, G. Subramanian, E. Yitamben

Device modeling: J. Gamble, T. Jacobson, R. Muller, E. Nielsen, I. Waldmueller, W. Witzel, R. Young

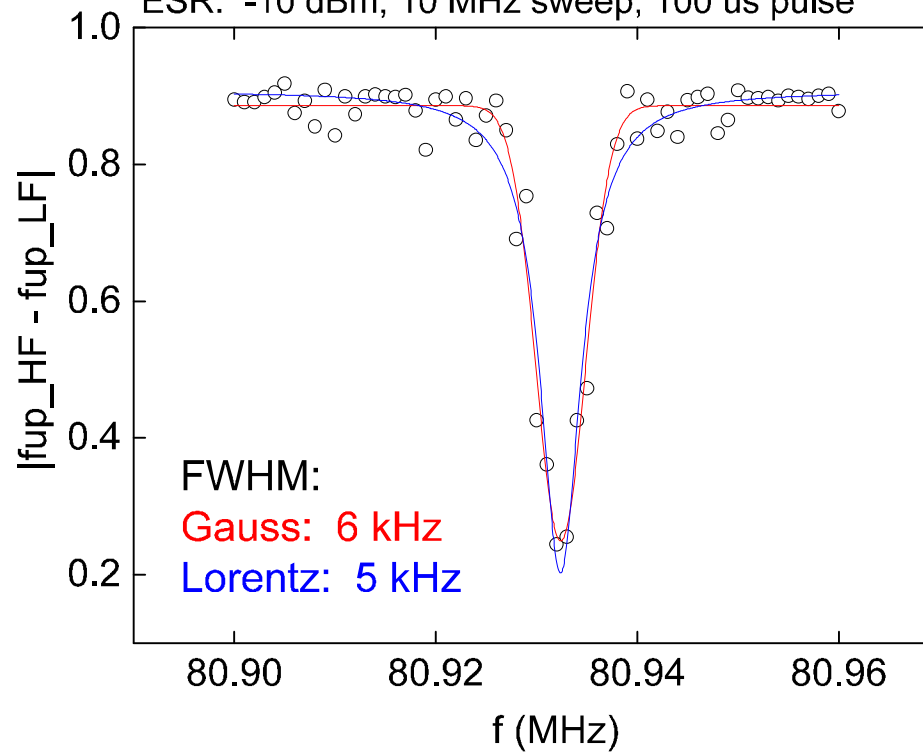
- Joint research efforts with external community:

- Australian Centre for Quantum Computing and Communication Technology (A. Dzurak, L. Hollenberg, D. Jamieson, A. Morello, S. Rogge, M. Simmons)
- Princeton University (S. Lyon)
- NIST (N. Zimmerman)
- U. Maryland (S. Das Sarma)
- National Research Council (A. Sachrajda)
- U. Sherbrooke (P. Harvey-Collard & M. Pioro-Ladriere)
- Purdue University (G. Klimeck & R. Rahman)
- U. New Mexico (A. Shirkhorshidian & P. Zarkesh-Ha)
- U. Wisconsin (M. Eriksson, M. Friesen)

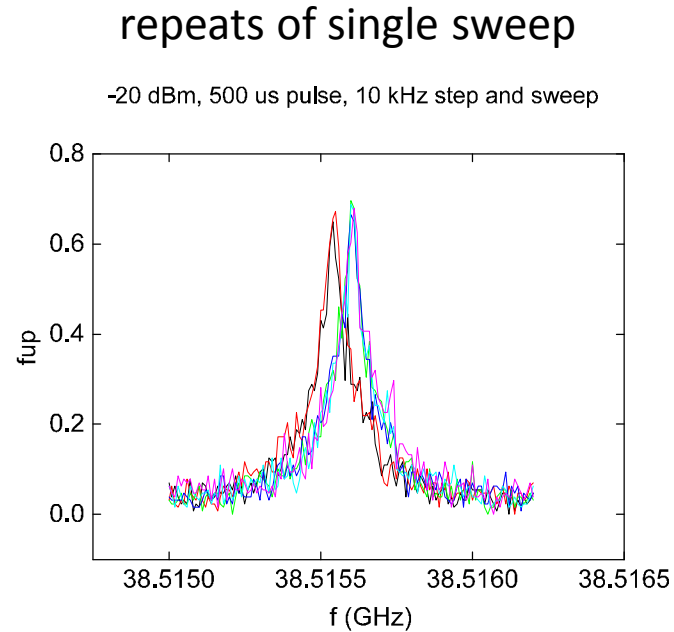
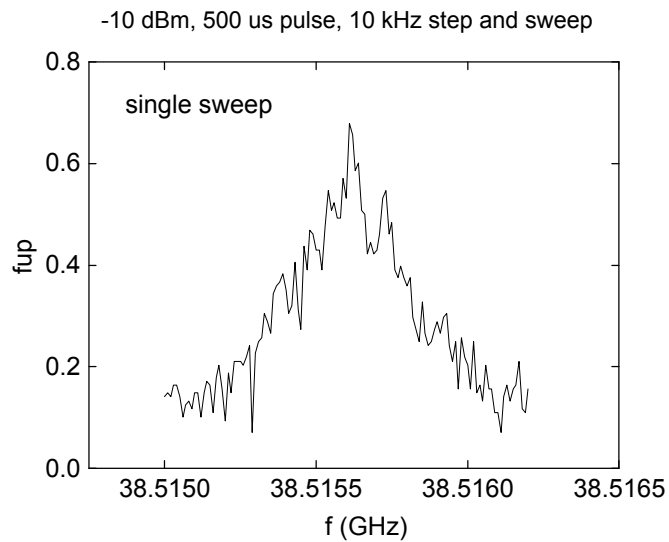
Auxiliary slides

Lower power NMR sweep

32 traces avg., 128 shots per point per each trace
NMR: -50 dBm, 5 ms pulse, 1 kHz step and sweep
ESR: -10 dBm, 10 MHz sweep, 100 us pulse



High power ESR sweeps



~10 min per trace

jump ~ 60 kHz

similar to jump in slide 12

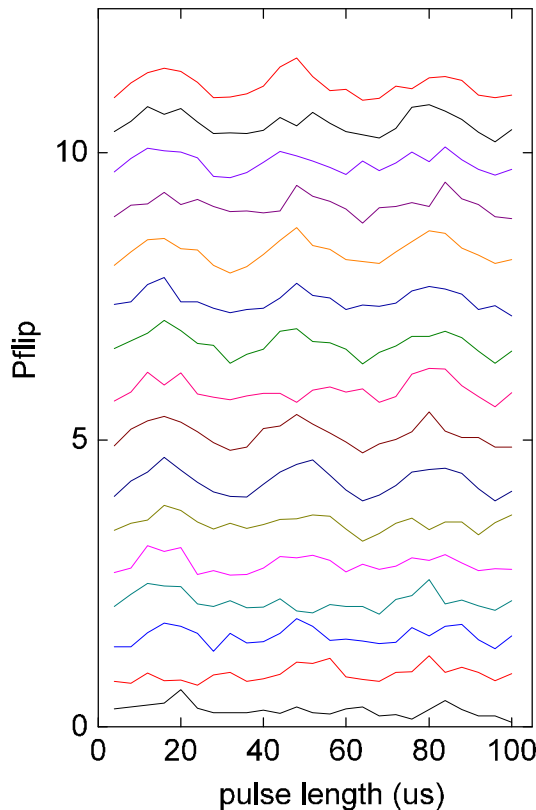
Ramsey beat frequency was ~ 200 kHz

Nuclear Rabi Osc. (electron down spin loaded on donor)

repeats of Rabi osc., nuclear spin w/ down electron spin

NMR: 0 dBm, 80.9324 MHz, 128 shots/pt.

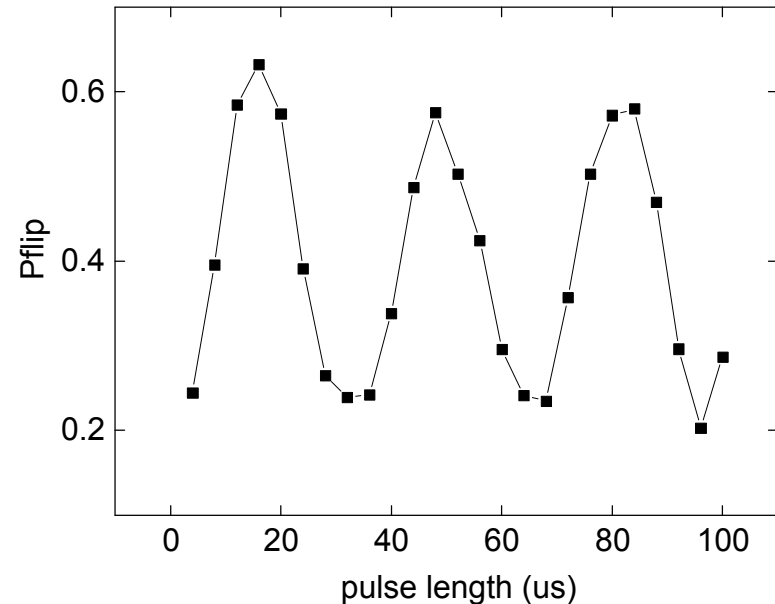
ESR: -10 dBm, 10 MHz sweep, 100 μ s pulse



16 trace avg. of Rabi osc., nuclear spin w/ down electron spin

NMR: 0 dBm, 80.9324 MHz, 128 shots per pt.

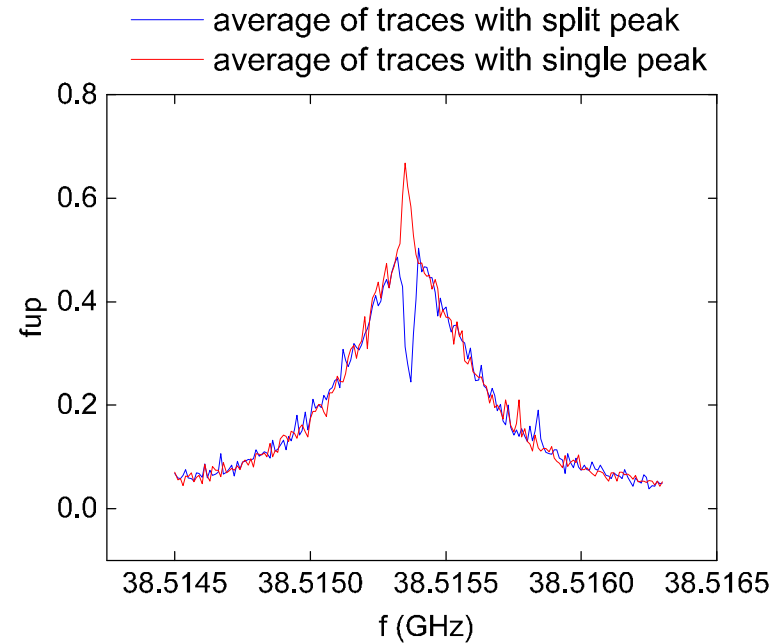
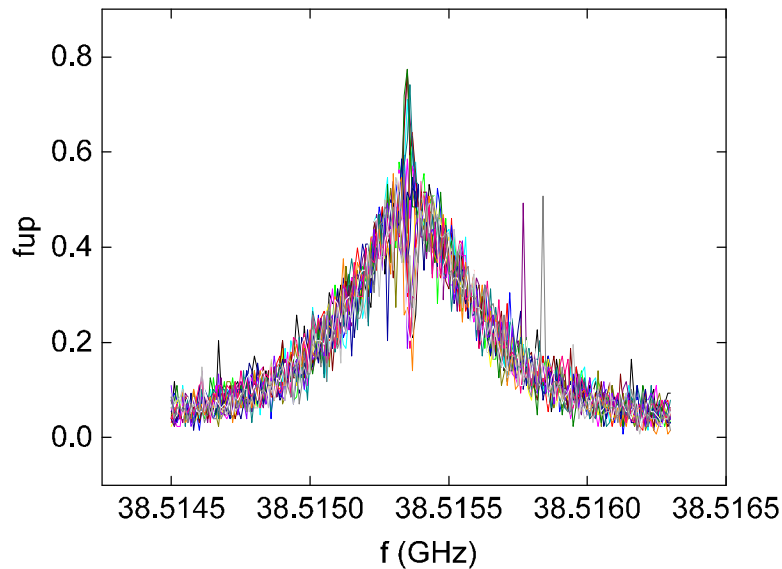
ESR: -10 dBm, 10 MHz sweep, 100 μ s pulse



- more power reaching sample than I expected
- ESR adiabatic flip and readout should be ~ 0 to 0.9, not sure why Pflip contrast for nuclear flip is low (oscillations noisy)
- Info about charge noise?

High power ESR sweep to flip neighboring P electron spins

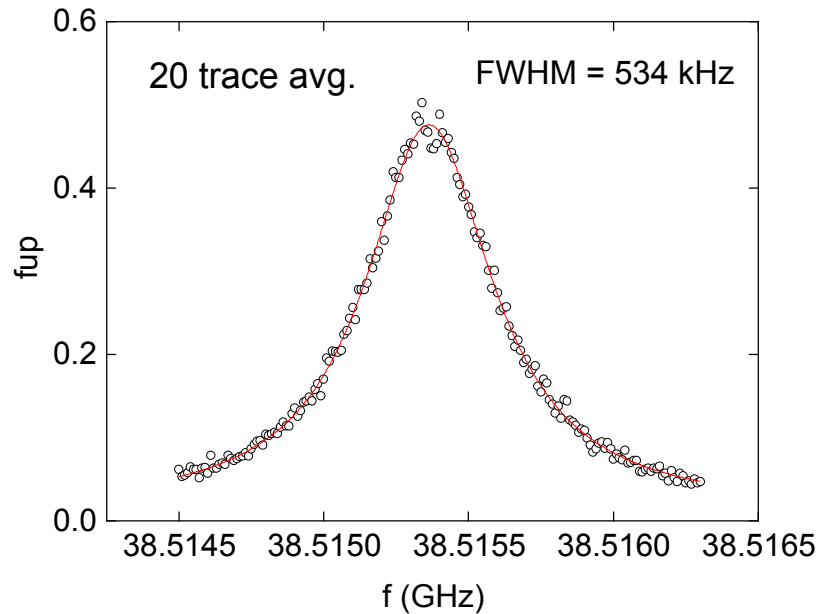
ESR: -10 dBm, 500 us pulses, 10 kHz step and sweep
128 shots per pt.



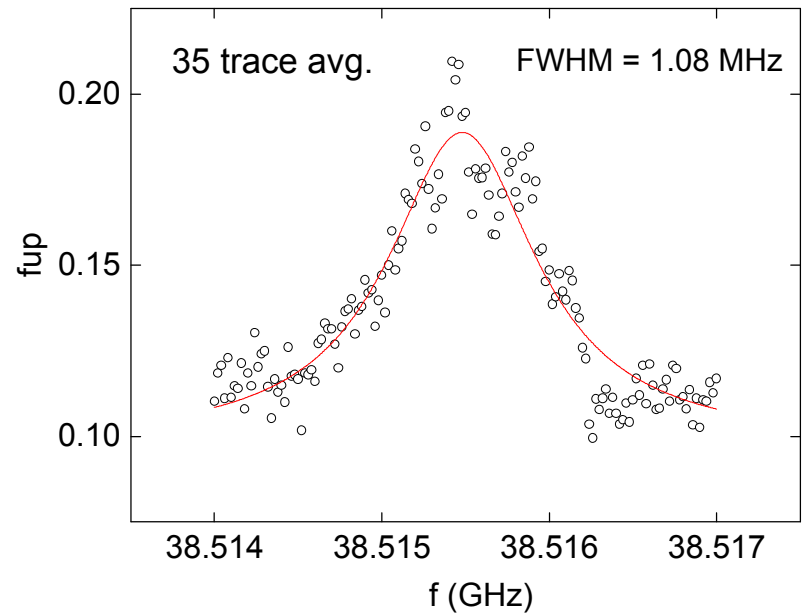
Could this be this neighbor P
nuclear spin up vs. down?

ESR sweep with P NMR pulse

No NMR



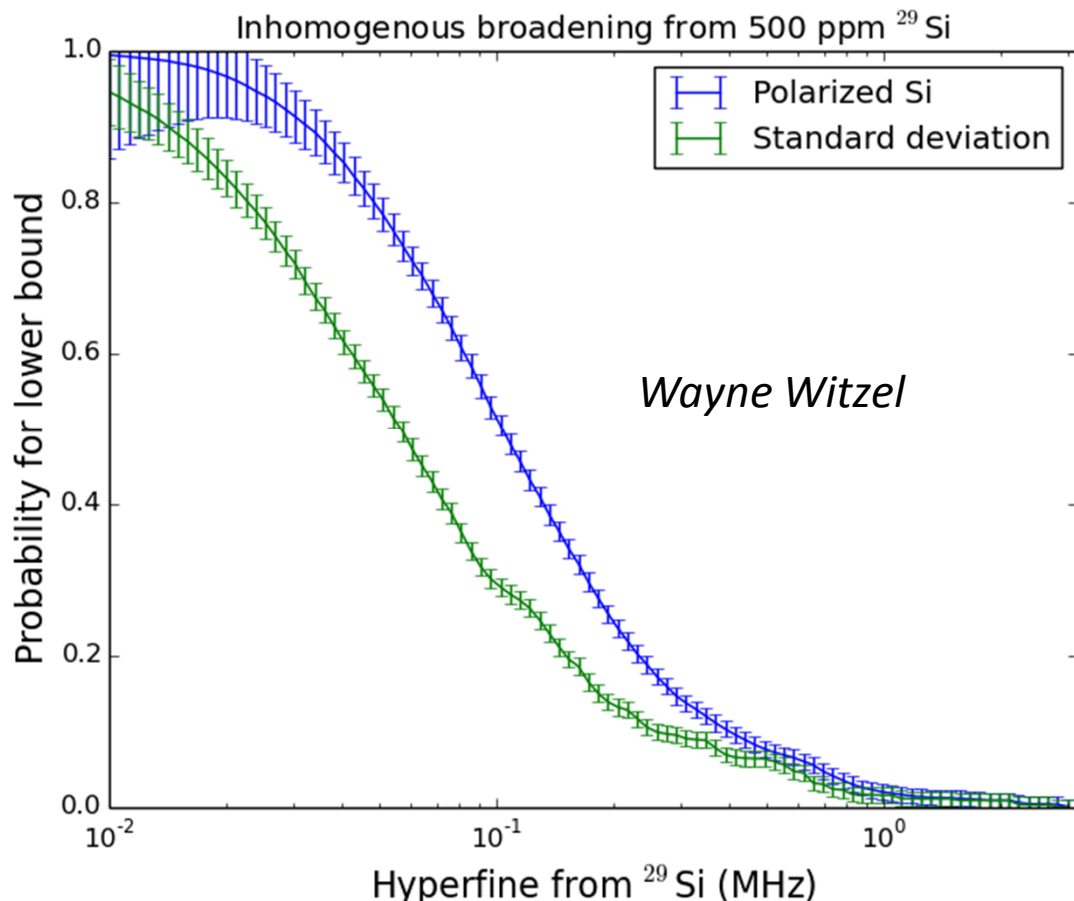
P NMR & ESR sweep
ESR: -10 dBm, 20 kHz step and sweep, 500 us pulse
NMR: -3 dBm, 5 ms pulse, 79 to 83 MHz



ESR peak width increase with 4 MHz P nuclear sweep?

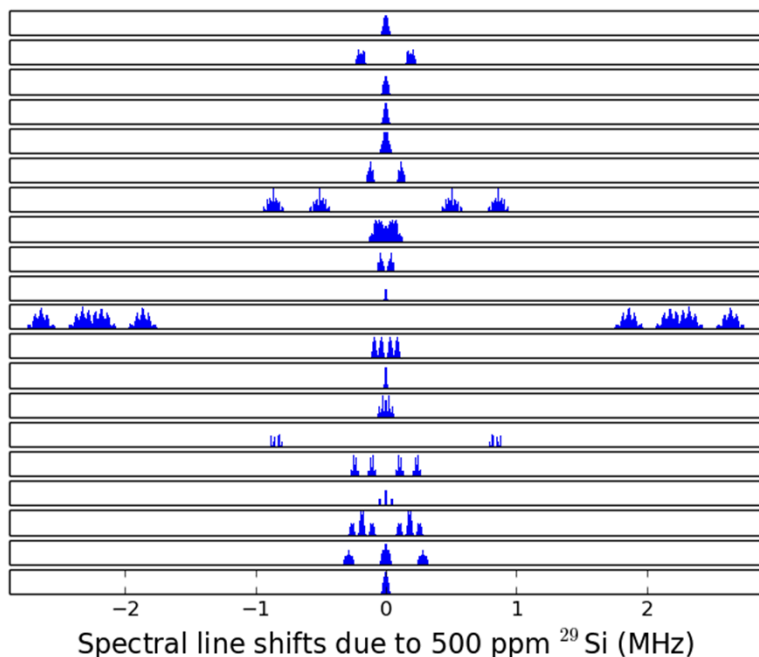
Hyperfine shifts from ^{29}Si ?

W. Witzel

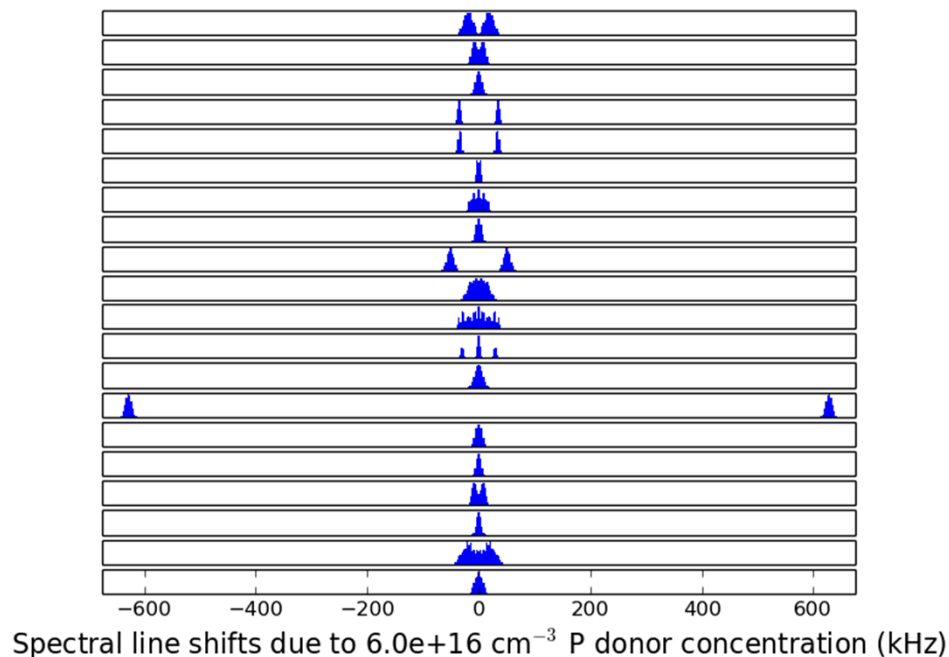


- Every sample will have different ^{29}Si constellation.
- 30 kHz linewidth seems reasonable, but it is suspicious that it occurred in two samples.
- Dynamics? How are background spins changing during measurement?

Calculated ESR line shapes

 ^{29}Si


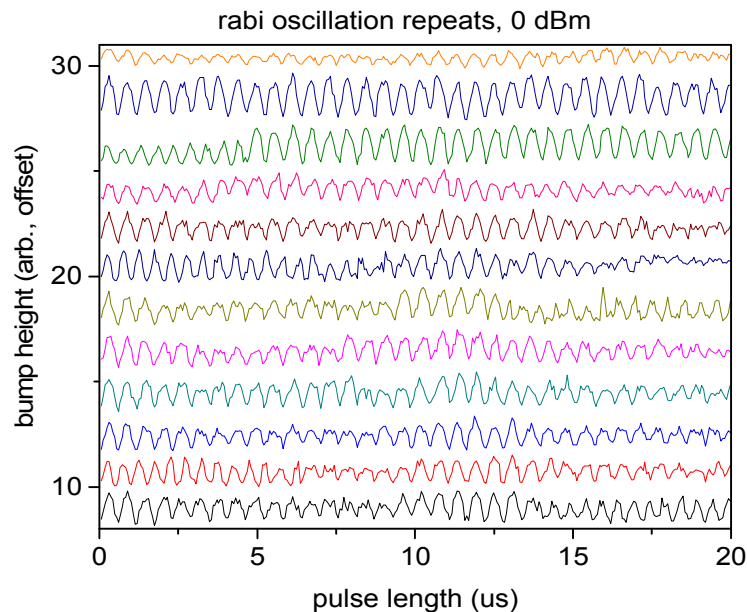
P donors



- Each row: different possible spectra for a given constellation of neighboring spins
- From experiment: P density $6 \times 10^{16} / \text{cm}^3$, 500 ppm ^{29}Si

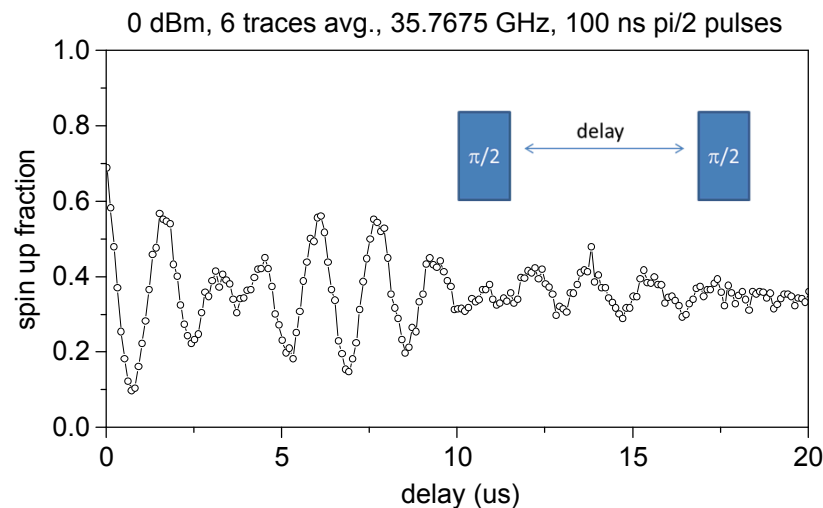
Beating in Rabi oscillations

Each trace
identical
repeat



0 dBm
128 averages

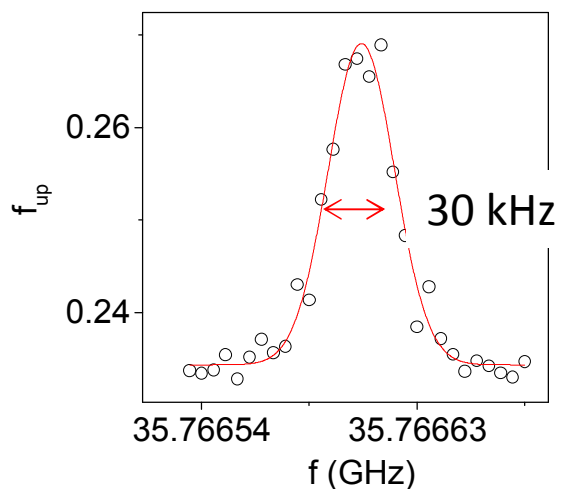
Ramsey Fringes



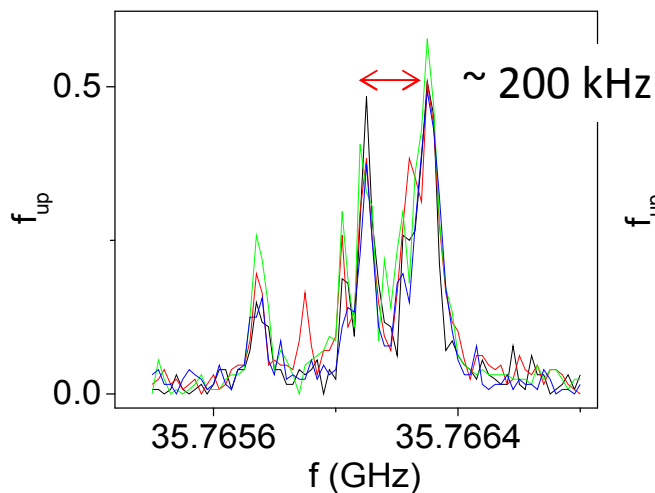
Beat frequency ~ 200 kHz

Complex line structure

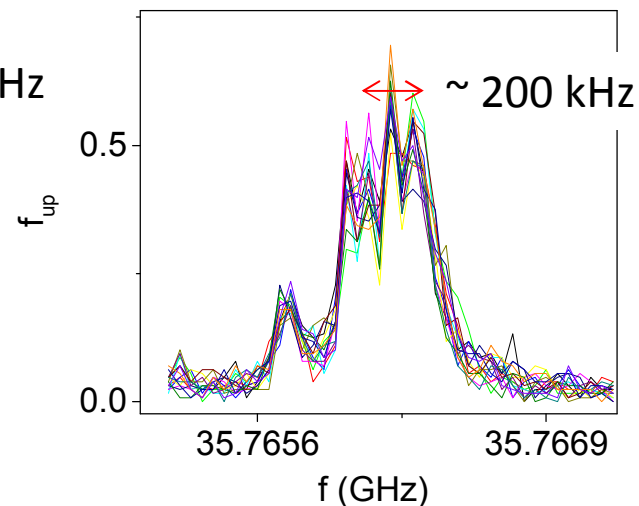
-50 dBm



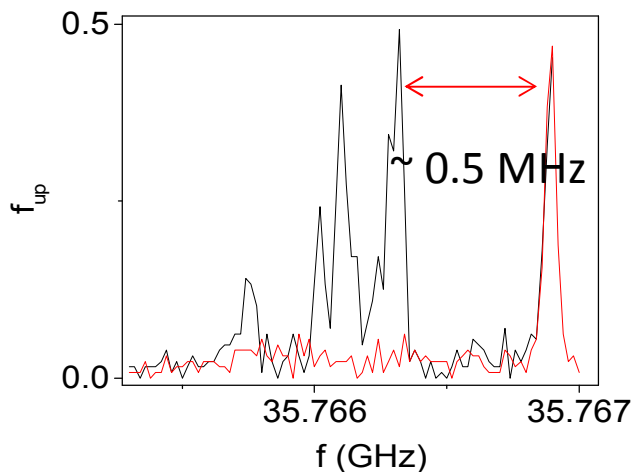
-40 dBm



-30 dBm



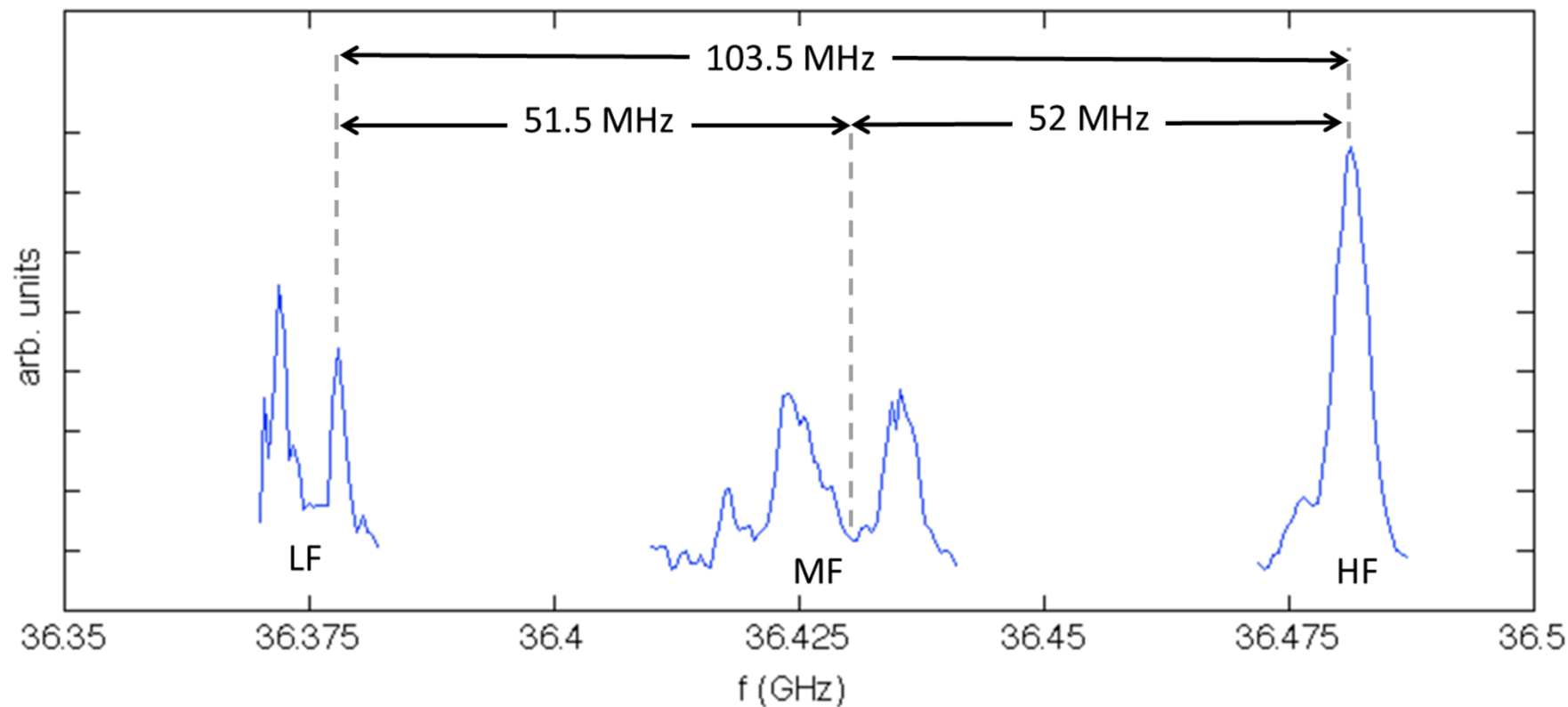
Jumps in line position



- Additional transitions apparent at higher microwave power
- Discrete jumps in position of line over hour long time scales

ESR Spectrum

D. R. Luhman



HF Splitting: 5.26 ± 0.09 MHz

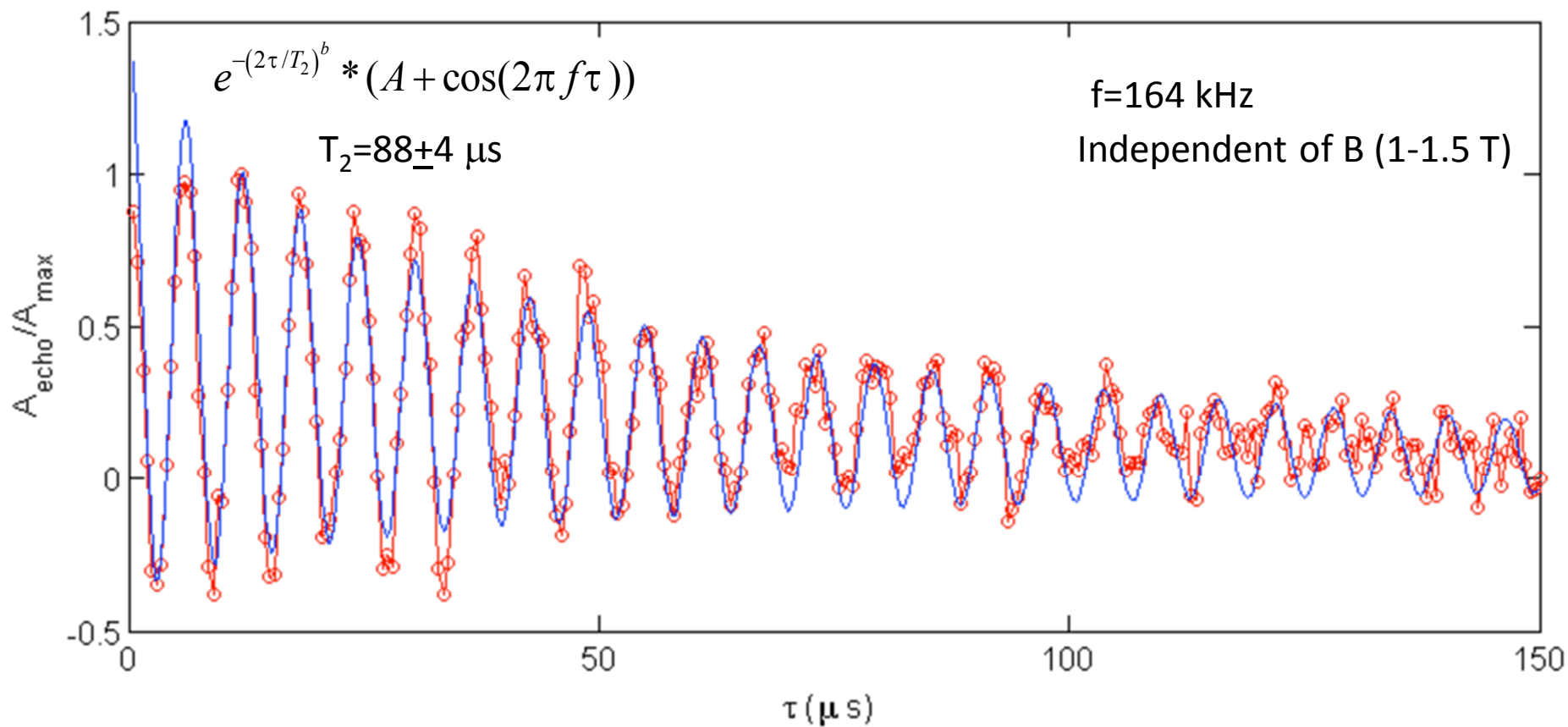
LF Splitting: 6.0 ± 0.2 MHz

Likely due to nearby ^{29}Si

HF line used for
Rabi Oscillation, T_2 , T_2^*

Hahn Echo Oscillations

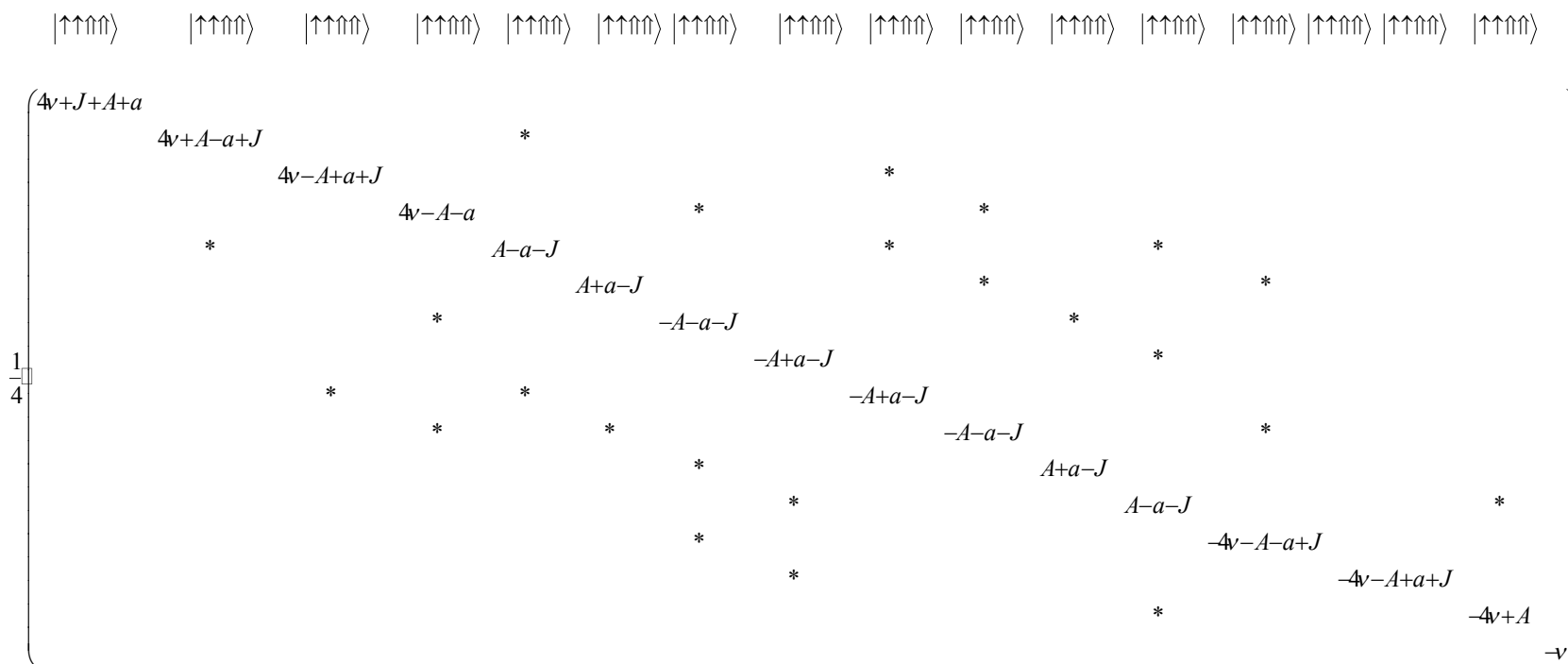
D. R. Luhman



Phosphorus dimer exchange model

$$H = v_e B + v_n B + J(S1*S2) + A1(S1*I1) + A2(S2*I2)$$

spin basis: $(m_{s,1}, m_{s,2}, m_{l,1}, m_{l,2})$

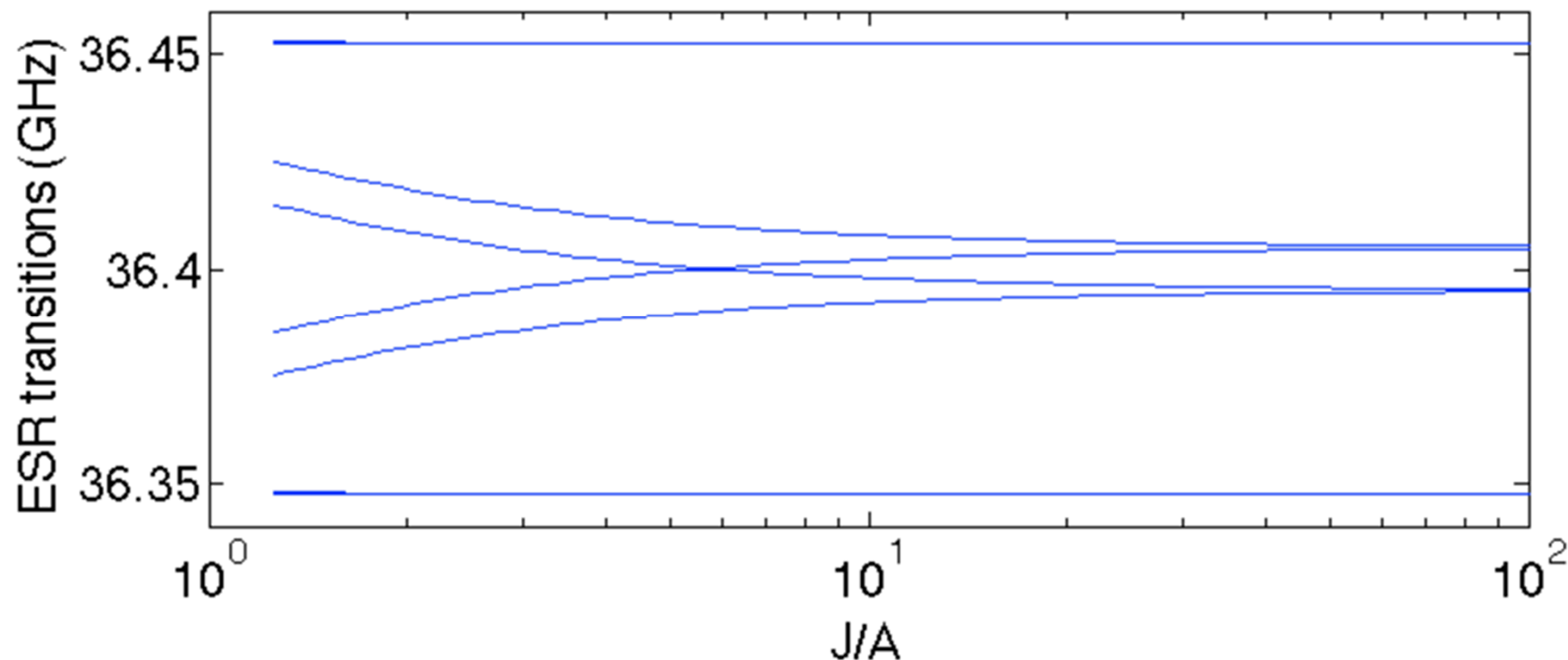


P2 ESR Spectrum

D. R. Luhman, M. P. Lilly

$(A_1 + A_2)/2 = 105$ MHz
 $A_1 = 115$ MHz $A_2 = 95$ MHz

8 most probable ESR transitions



Kalra et al. PRX **4** (2014)
 Shankar, Tyryshkin, Lyon arxiv.1409.3534

A dimer with $J > A$ can
 produce central lines

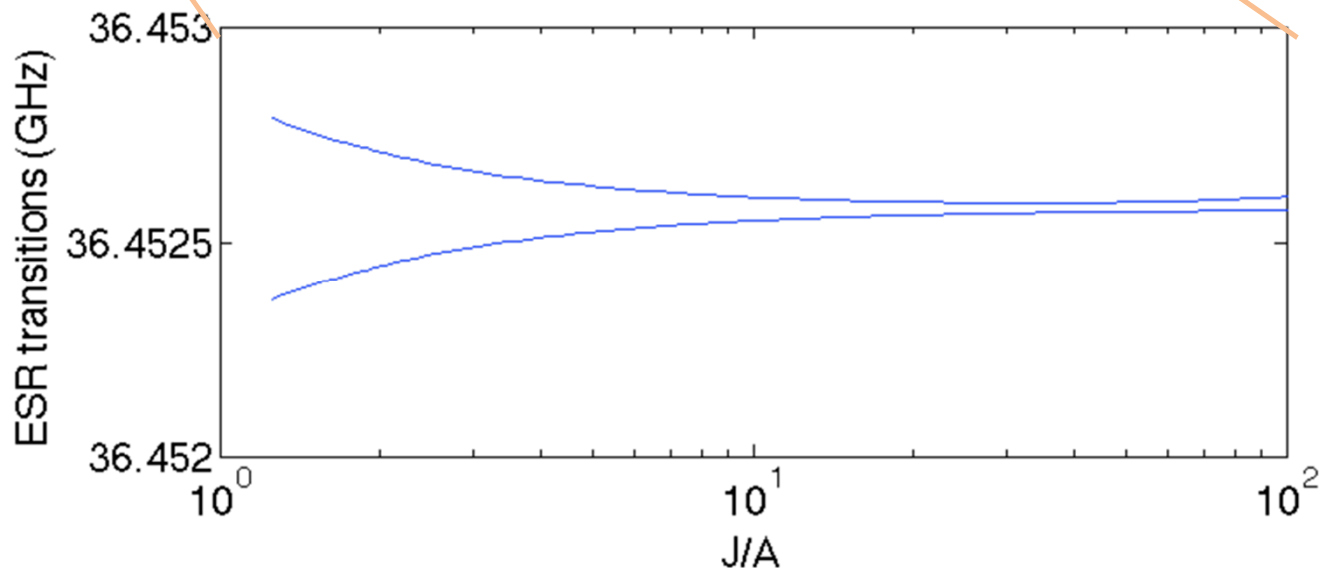
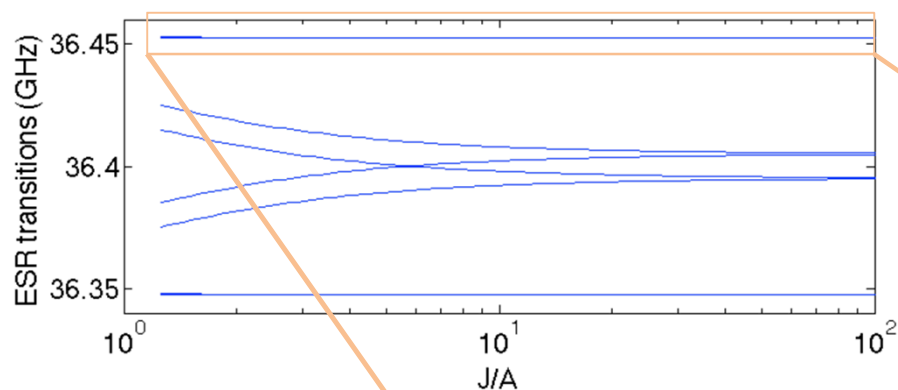
P2 ESR Spectrum

D. R. Luhman, M. P. Lilly

Difference, Δf , may lead to oscillations in Hahn Echo

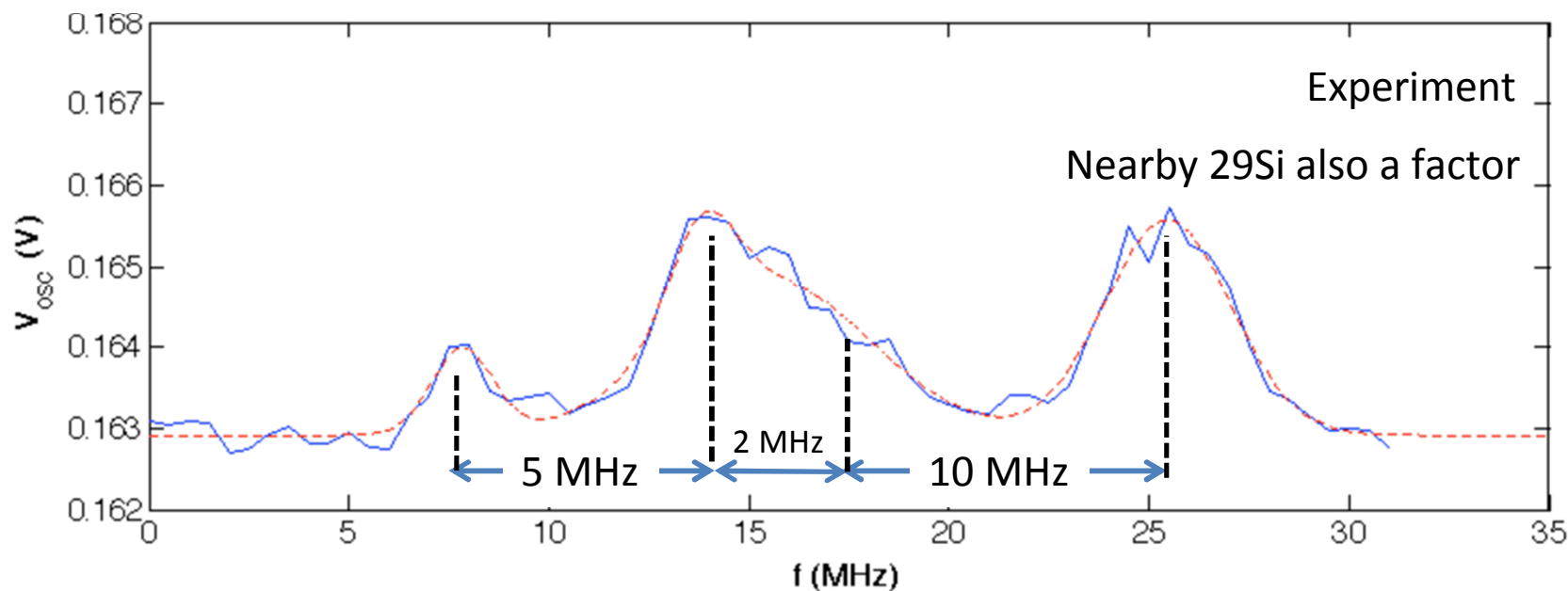
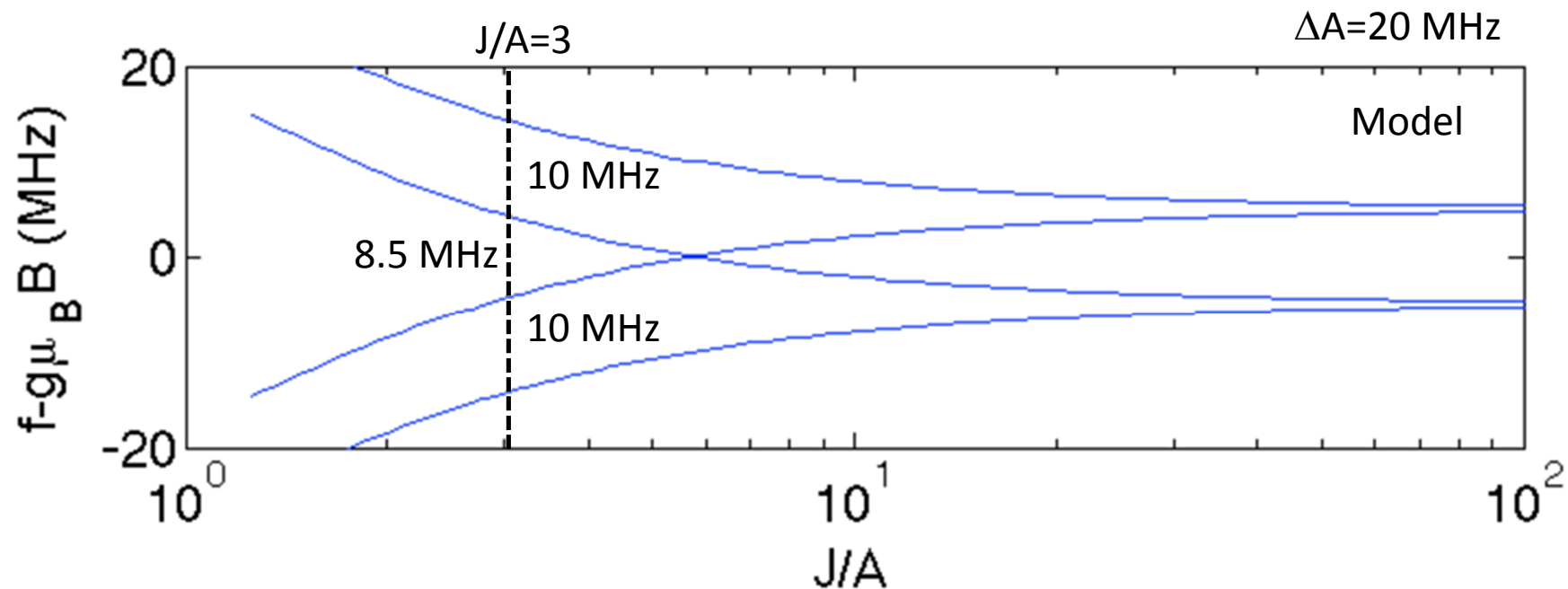
$$\Delta f(J/A_{\text{avg}}, B, \Delta A)$$

Need to find a parameter space where $\Delta f = 164$ kHz and is independent of B



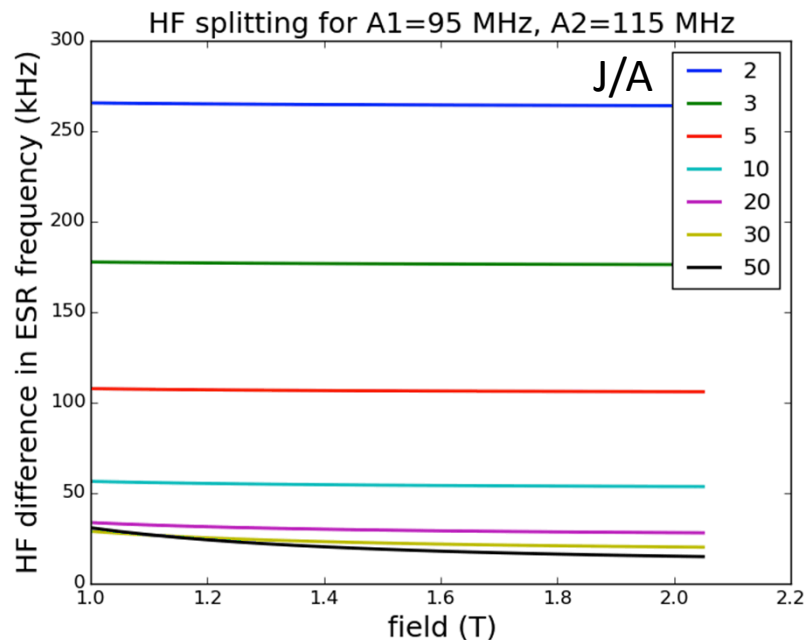
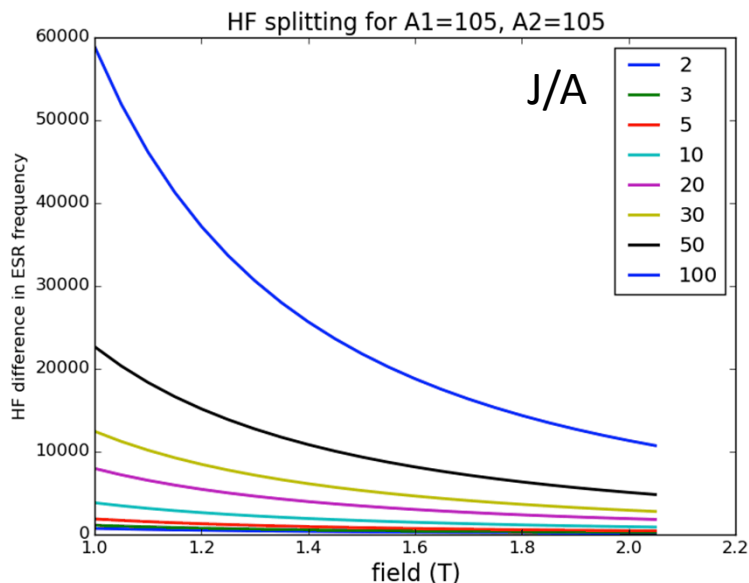
Center Line

D. R. Luhman, M. P. Lilly



High Frequency Lines

Is this correct?



$\Delta A=14-24$ MHz

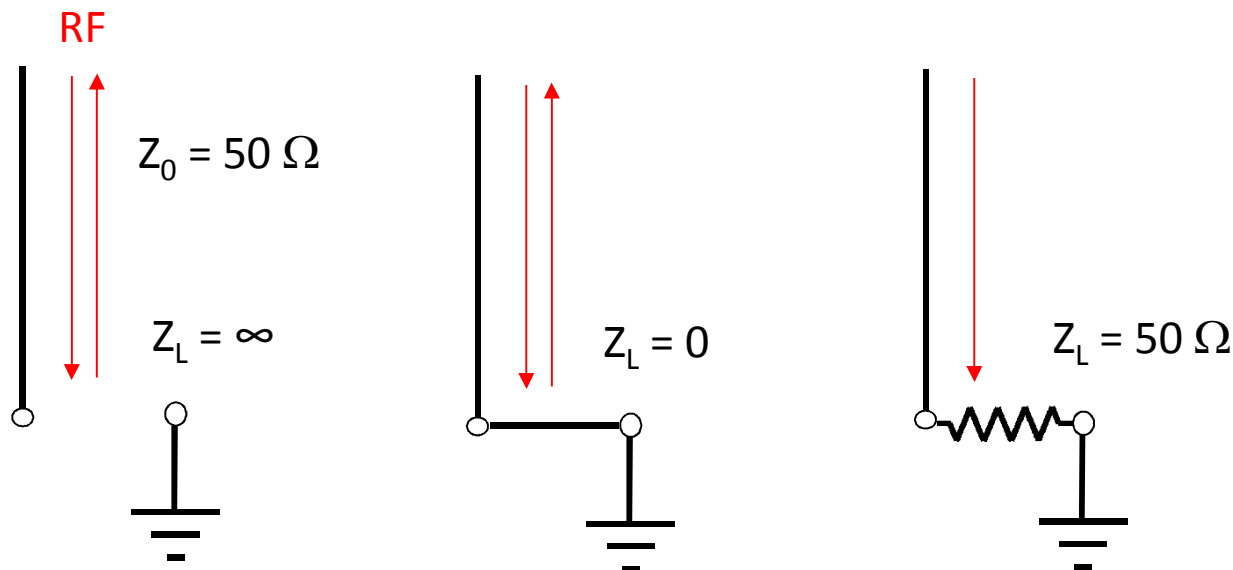
$J/A \sim 2.5-4$

$\Delta f \sim 165$ kHz and independent of B

Consistent with Experiment

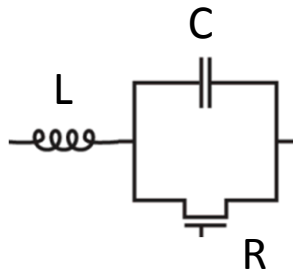
RF Reflectometry

Measure reflection off of load Z_L



- Device $Z \neq 50 \Omega$ – match impedance Z_L to transmission line Z_0

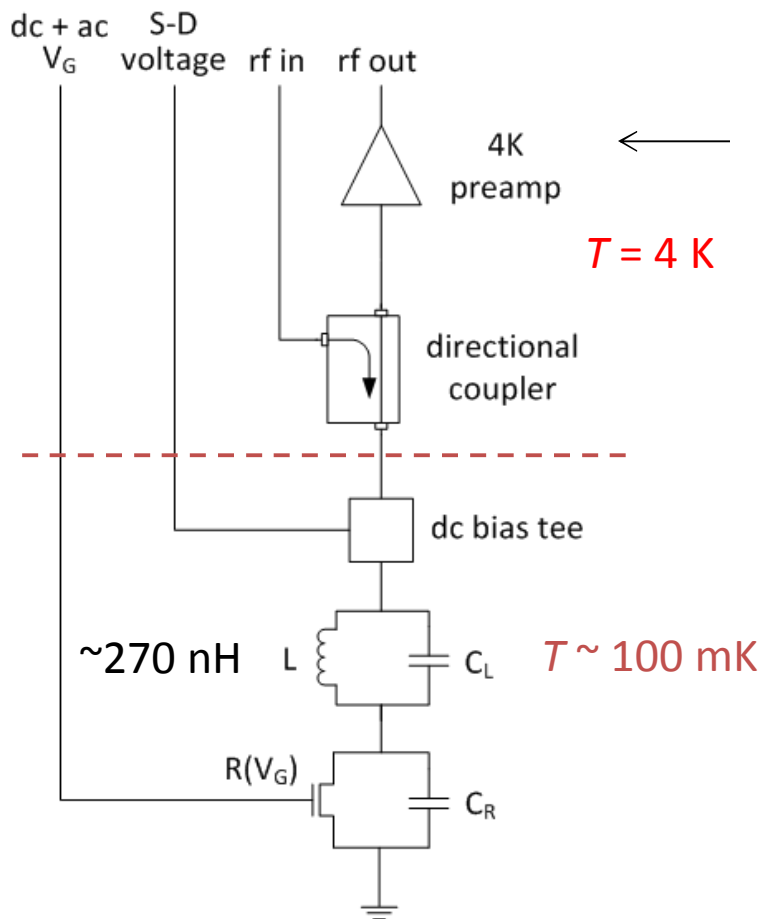
tank circuit:



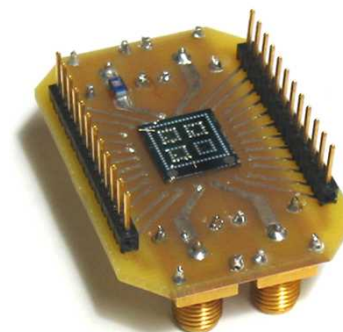
$$Z_L \rightarrow 50 \Omega \text{ for } 2\pi f \sim 1/\sqrt{LC}$$

Schoelkopf et al., Science 1998

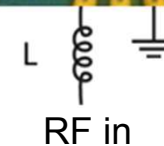
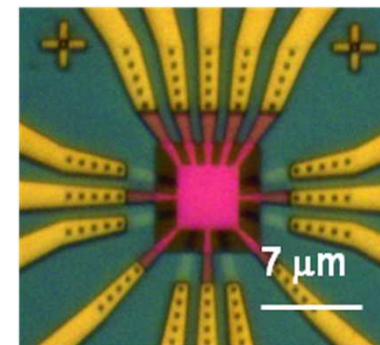
Reflectometry Circuit



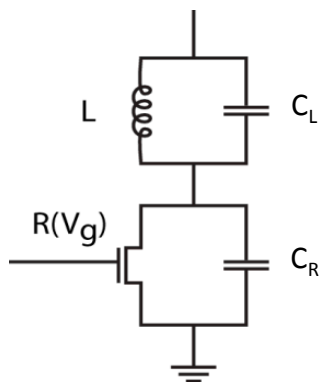
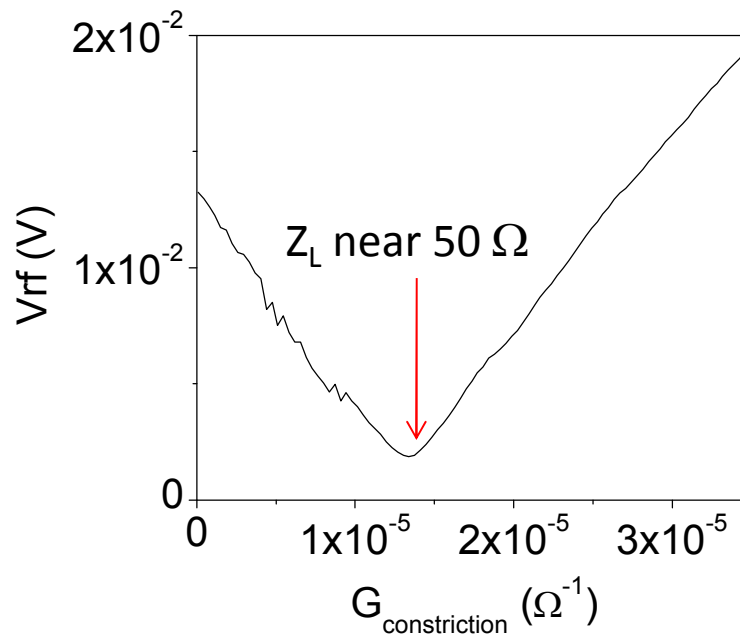
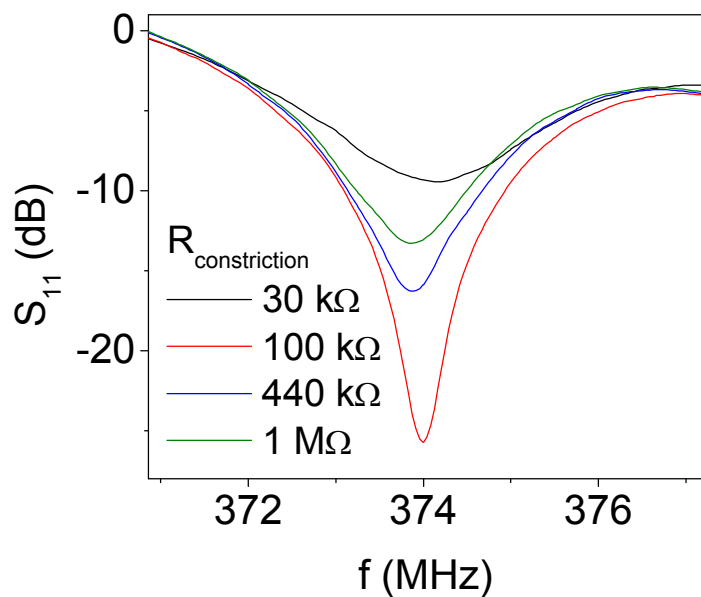
Quinstar HEMT amplifier (gain $\sim 45\text{ dB}$ @ 300 to 420 MHz, $T_N \sim 3 - 6\text{ K}$)



RF DQD Platform



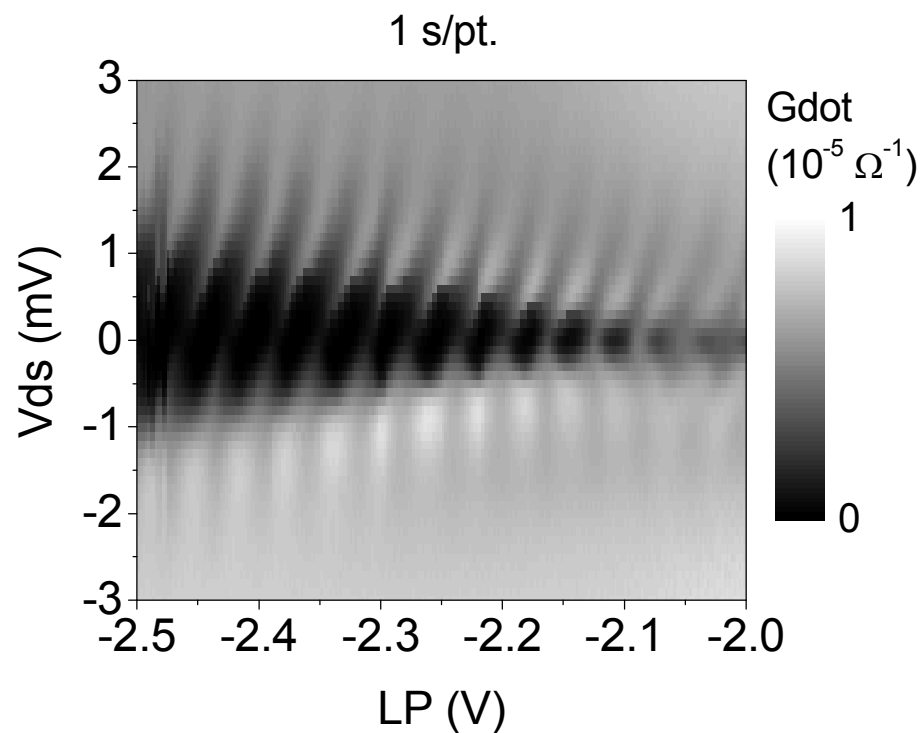
Tank Circuit Resonance vs. R_{device}



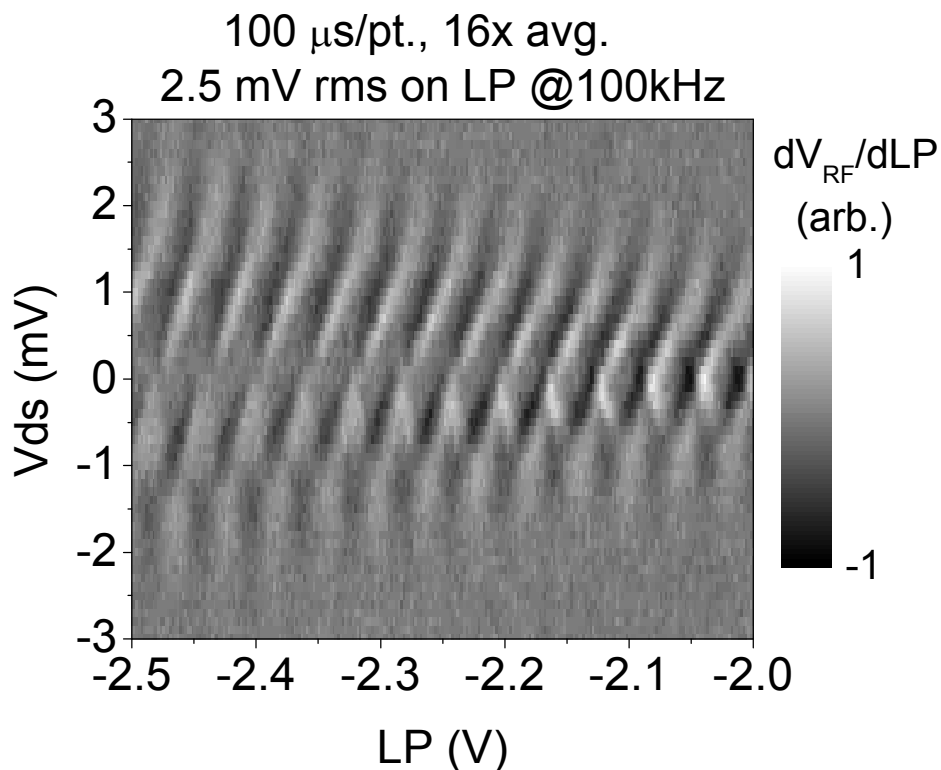
- Extract stray capacitances: $C_L \sim 0.48$ pF, $C_R \sim 0.19$ pF

Coulomb Diamonds: Quasi-dc vs. Reflectometry

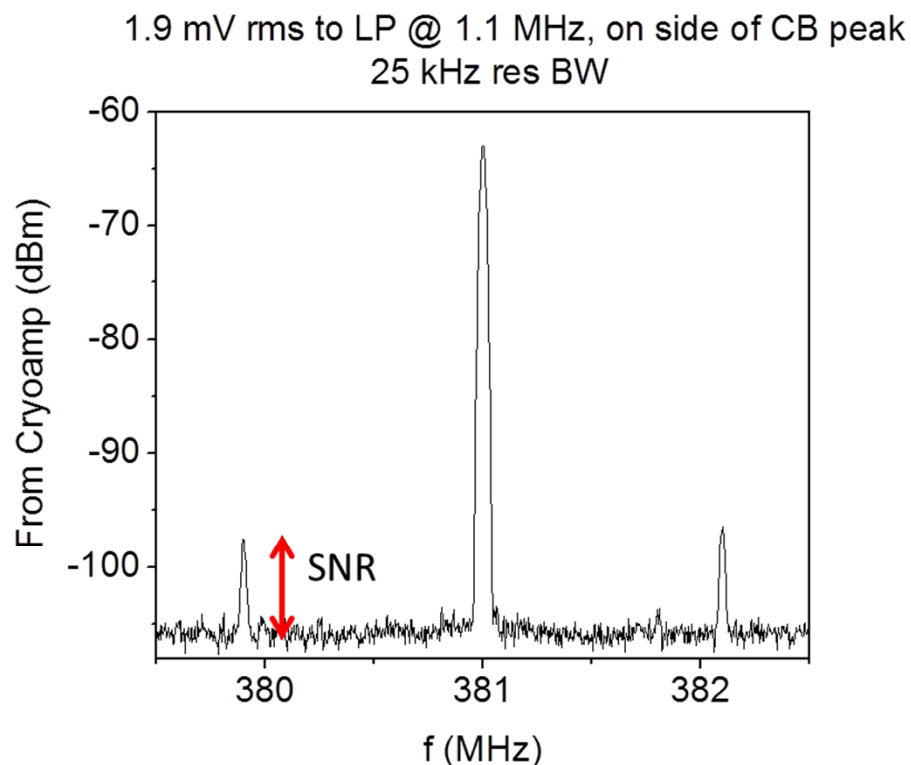
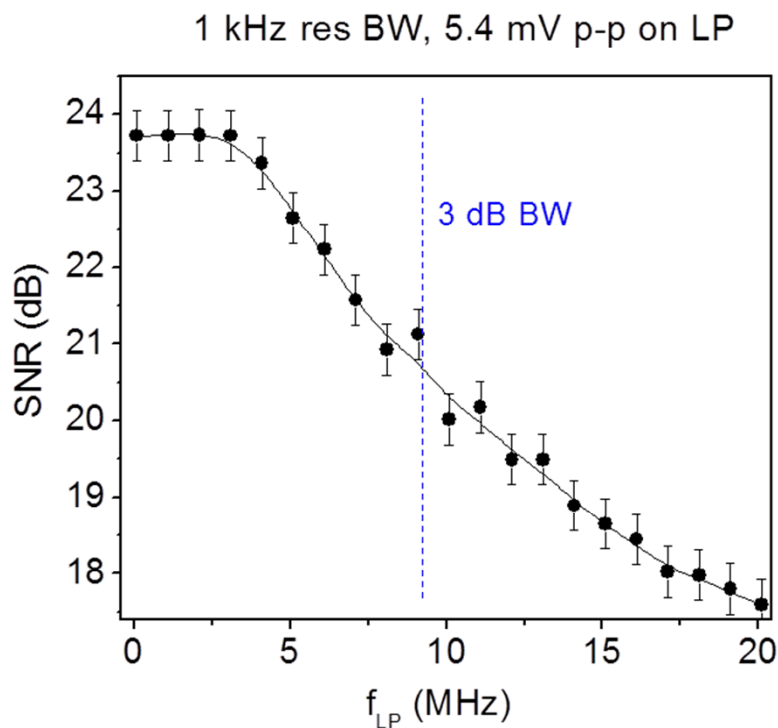
quasi-dc



reflectometry



RF SET Bandwidth and Sensitivity



- Si MOS RF SET: 10 MHz BW and $\sim 10^{-9} \Omega^{-1} / \text{VHz}$ sensitivity and for $V_{sd} \sim 200 \mu\text{V}$
- Corresponds to noise $\sim 200 \text{ fA Hz}^{-1/2}$
- Other groups have achieved $\sim 100 \text{ fA Hz}^{-1/2}$ (Reilley *et al.*, Phys. Rev. Lett. (2007))